

# Electron Beam Ion Sources

**Günter Zschornack**

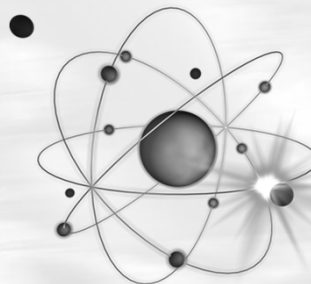
Dreebit GmbH Dresden

and  
Technische Universität Dresden  
Department of Physics

and  
Helmholtzzentrum Dresden-Rossendorf  
Institute of Ion Beam Physics and Materials Research

## Why Highly Charged Ions ?

Exciting properties of  
highly charged ions



## Properties of Highly Charged Ions

### Potential Energy

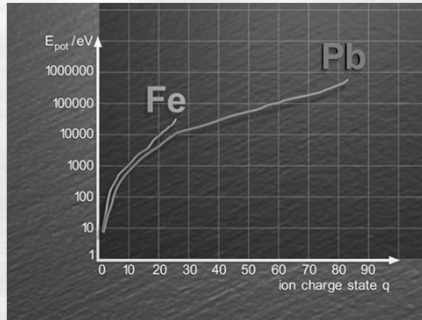


The potential energy of an ion increases with the degree of ionization.

Example:

Xe<sup>44+</sup> has a potential energy that is **4200 times higher** than that of Xe<sup>1+</sup>

Xe<sup>54+</sup> has a potential energy that is **16700 times higher** than that of Xe<sup>1+</sup>



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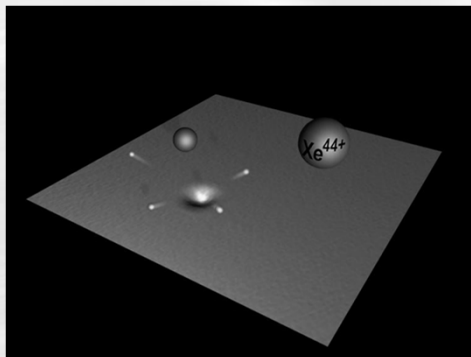
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## Properties of Highly Charged Ions

### High power Deposition into the Surface



The deposition of potential energy leads to ultrafast intense electronic excitations up to:  **$10^{12} \dots 10^{14} \text{ W/cm}^2$**

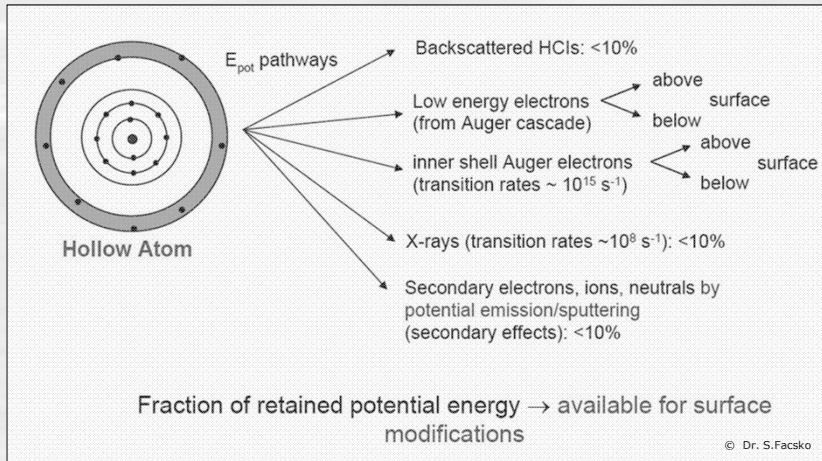


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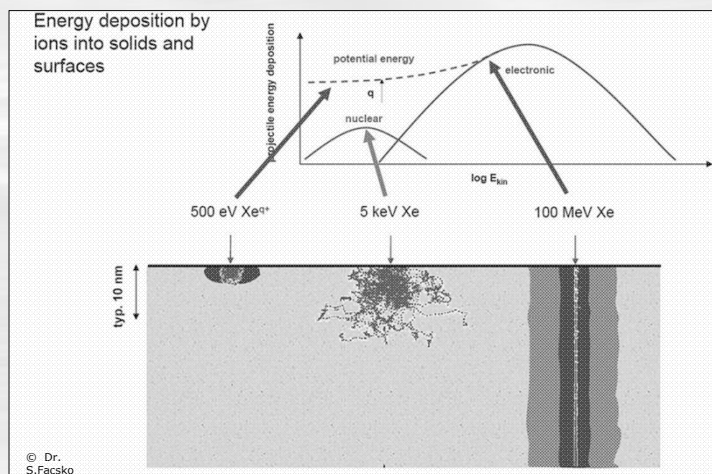
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# Pathways of Potential Energy



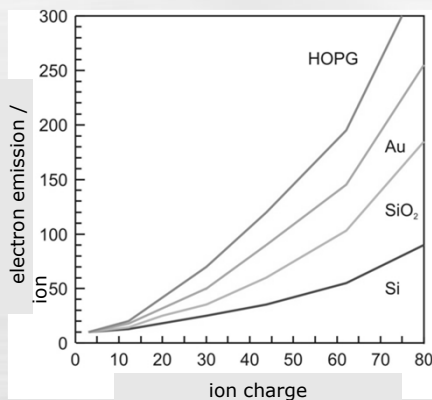
# Energy Deposition into Surface



## Highly Charged Ions give higher Yields of Secondary Ions and Secondary Electrons



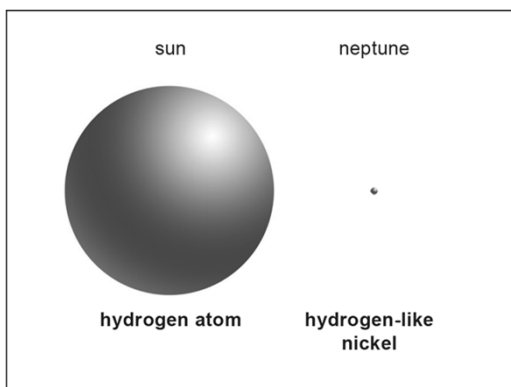
J.W.McDonald et al: NIM B 240, 829 (2005)



Total electron yields vs ion charge state  $q$

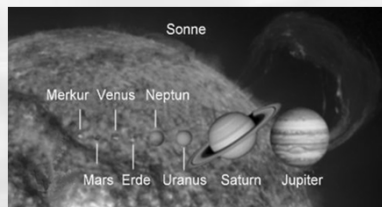
## Properties of Highly Charged Ions

Small Spatial Extent of the Projectiles



(Idea by J.Gillaspay, NIST)

The size ratio of a hydrogen-like nickel ion to a neutral hydrogen atom is approximately equal to the size ratio of the planet neptune to the sun.



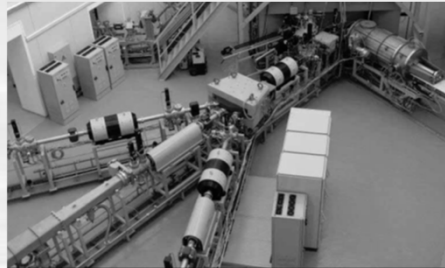
## Properties of Highly Charged Ions

Extremely Compact Accelerator Structures are possible



Due to their high charge  $q$  ions can be accelerated very effectively

- $\sim q$  for linear accelerators
- $\sim q^2$  for ring accelerators



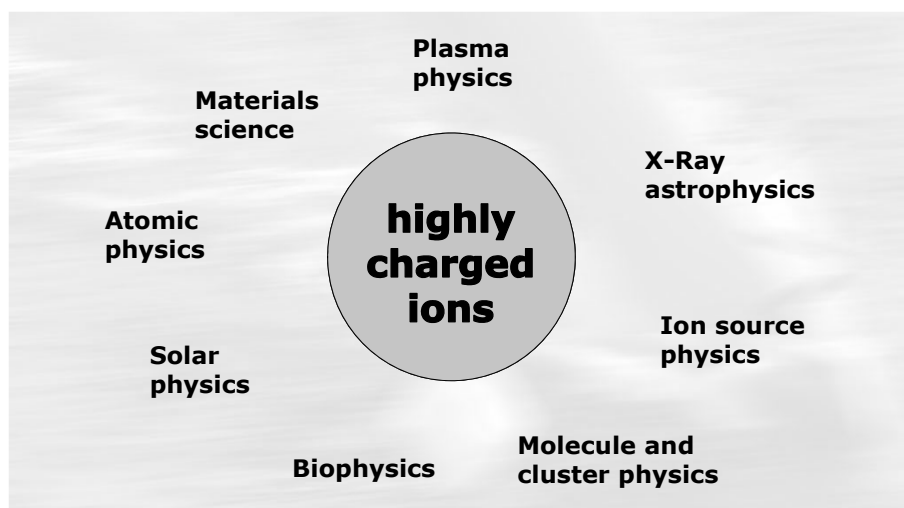
**Example:**

**Xe<sup>1+</sup> and Xe<sup>44+</sup> acceleration at  $\Delta U = 20$  kV**

| $\Delta U = 20$ kV | linear accelerator | ring accelerator                        |
|--------------------|--------------------|---|
| Xe <sup>1+</sup>   | 20 keV             | 20 keV                                  |
| Xe <sup>44+</sup>  | 880 keV            | 38720 keV = 38,72 MeV                   |
|                    |                    | <i>(energy gain about factor 2000!)</i> |

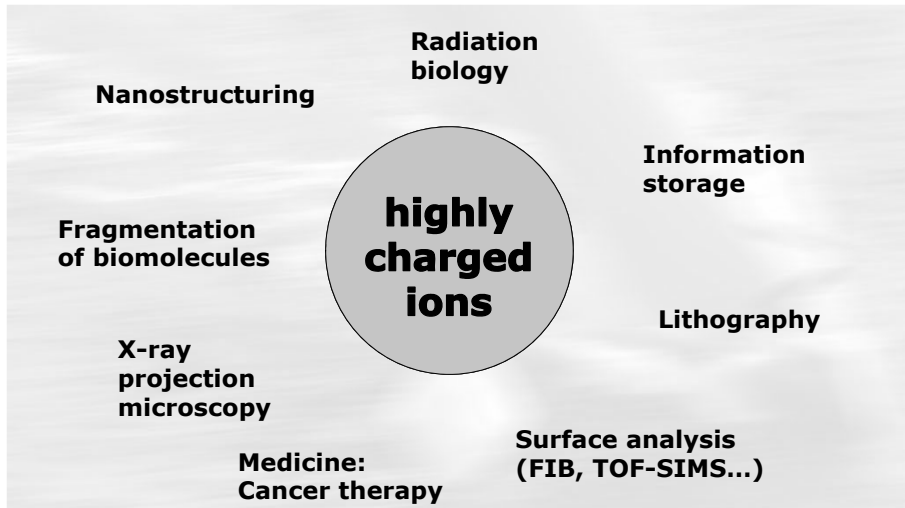
## Applications of HCI

Highly Charged Ions in Basic Research and Industry



# Applications of HCI

Highly Charged Ions in Basic Research and Industry

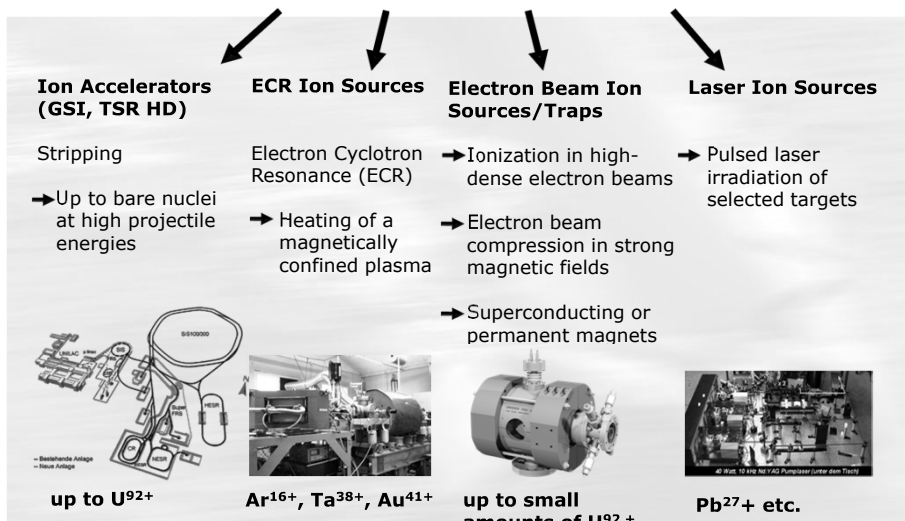


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# How to Produce Highly Charged Ions?

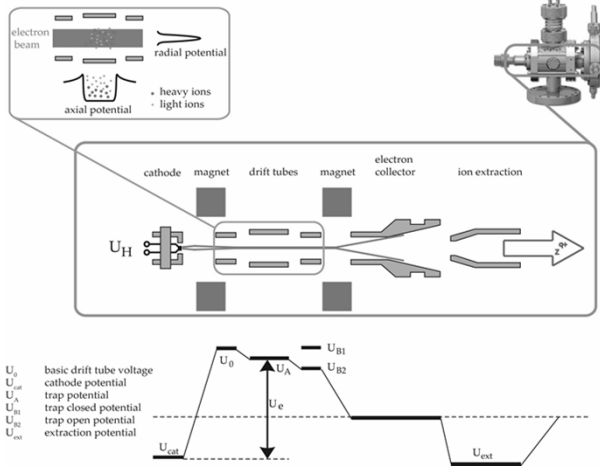


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# Electron Beam Ion Trap – Basic Idea



| quantity              | range   |
|-----------------------|---|
| Electron beam energy  | up to 200 keV                                 |
| Electron beam current | up to A (typically up to some hundreds of mA) |
| Source vacuum         | $10^{-8}$ mbar up to $10^{-12}$ mbar          |

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# EBIS/T – Short History

## Selected Milestones



| Year         | Place/Name                       | Device                 | Ions  | Source type (B, trap length)       |
|--------------|----------------------------------|------------------------|---|------------------------------------|
| 1968         | Dubna (USSR) Donets              | IEL I, IEL II          | Au <sup>19+</sup>   | warm EBIS<br>0.4 T, 16 cm          |
| 1971         | Dubna (USSR) Donets/Pikin        | KRION I                | C <sup>6+</sup> , N <sup>7+</sup> , O <sup>8+</sup> , Ne <sup>10+</sup>   | SC<br>1.2 T, 1.2 m                 |
| 1974         | Dubna (USSR) Ovsyannikov /Donets | KRION 2                | Ar <sup>18+</sup> , Kr <sup>36+</sup> , Xe <sup>54+</sup>                 | SC<br>2.2 T, 1.2 m                 |
| 1981<br>1986 | Orsay (France) Arianer           | CRYEBIS 1<br>CRYEBIS 2 | C <sup>6+</sup> , N <sup>7+</sup> , Ne <sup>10+</sup> , Ar <sup>18+</sup> | SC, 3 T, 1.66 m<br>SC, 5 T, 1.66 m |
| 1984         | Saclay (France) Faure            | DIONE                  | Ar <sup>16+</sup> , Kr <sup>30+</sup> , I <sup>41+</sup>                  | SC, 6 T, 1.2 m                     |

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## EBIS/T – Short History

### Selected Milestones



| Year         | Place/Name                           | Device            | Ions                                   | Source type (B, trap length)                      |
|--------------|--------------------------------------|-------------------|--|---|
| 1988<br>1990 | LLNL<br>(USA) Levine<br>Marrs/Knapp  | EBIT-I<br>EBIT-II | Xe <sup>54+</sup> , U <sup>88+</sup>   | SC, 3 T, 2 cm<br>(E <sub>(e,max)</sub> = 29 keV)  |
| 1990         | LLNL<br>(USA)<br>Marrs/<br>Schneider | S-EBIT            | U <sup>92+</sup> , Cf <sup>96+</sup>   | SC, 3 T, 2 cm<br>(E <sub>(e,max)</sub> = 215 keV) |
| 1999         | Freiburg<br>(Germany)<br>Crespo      | F/HD-EBIT         | Xe <sup>54+</sup>                      | SC, 9 T,<br>4-30 cm                               |
| 2009         | Brookhaven<br>(USA)<br>Beebe/Pikin   | RHIC-EBIS         | Xe <sup>36+</sup><br>high current EBIS | SC<br>6 T, 1.5 m                                  |

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## EBIS/T – Short History

### Selected Milestones



| Year         | Place/Name   | Device   | Ions   | Source type (B, trap length)                                     |
|--------------|--|--|--|--|
| 1999         | TU Dresden<br>(Germany)<br>Ovsyannikov/<br>Zschornack      | Dresden EBIT   | Ar <sup>18+</sup> ,<br>Xe <sup>44+</sup> , Ir <sup>67+</sup> | warm EBIT<br>0.25 T, 2 cm<br>(E <sub>(e,max)</sub> = 15 keV)     |
| 2005<br>2008 | Dreebit<br>GmbH<br>(Germany)<br>Ovsyannikov/<br>Zschornack | Dresden EBIS<br>Dresden EBIS-A                       | Ar <sup>18+</sup> ,<br>Xe <sup>48+</sup> , Ir <sup>67+</sup> | warm EBIS,<br>0.4/0.6 T, 6 cm<br>(E <sub>(e,max)</sub> = 25 keV) |
| 2009         | Dreebit<br>GmbH<br>(Germany)<br>Ovsyannikov/<br>Zschornack | Dresden EBIS-SC<br>(medical applications<br>and R&D) | C <sup>6+</sup> , Ar <sup>18+</sup> ,<br>Xe <sup>48+</sup>   | SC, 6 T,<br>4-30 cm<br>(E <sub>(e,max)</sub> = 20 keV)           |

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# EBIS/T – Short History

Selected Milestones



There are actually about 60 EBIS/EBIT around the world.  
(For a list see R.Becker, O.Kester; RSI 81(2010) 02A513)

Most of them are special laboratory constructions.

Worldwide there are only two commercial offerers:

## 1. Physics and Technology Livermore (USA)

REBIT (Refrigerated Electron Beam Ion Trap)



## 2. DREEBIT GmbH Dresden (Germany)

Dresden EBIT } Room-Temperature  
Dresden EBIS } EBIS/T  
Dresden EBIS-A }  
Dresden EBIS-SC }  
(Refrigerated Electron Beam Ion Trap)



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# EBIS/T

Different solutions



- Tokyo EBIT**  

Diagram labels: 4 m trap region, Electron Collector, Trap Region, Electron Gun, SF<sub>6</sub> Tank contains Power Supply System.

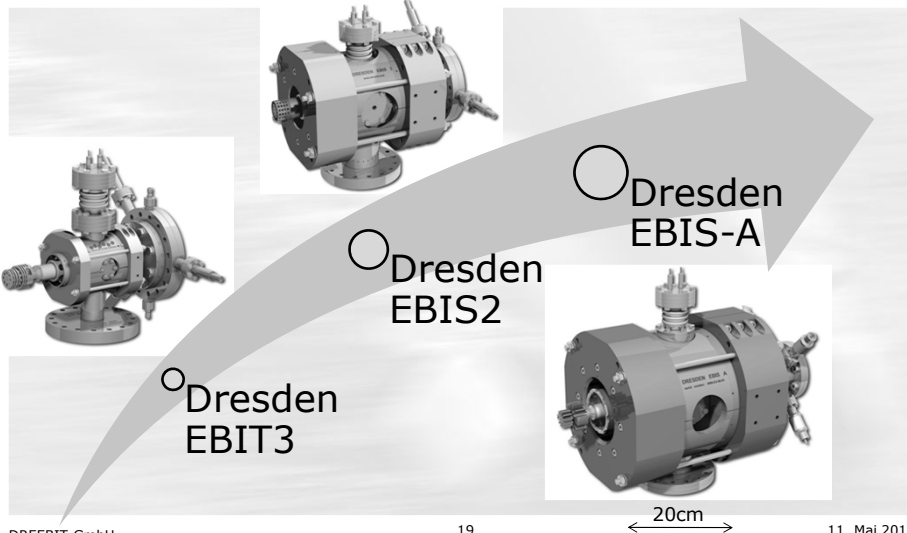
Photo labels: SF<sub>6</sub> Tank, Collector, Trap Region, Electron Gun.
- Shanghai EBIT**
- Dresden EBIT**
- LLNL EBIT**  
(at the MPI for Plasma Physics Berlin)

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## Room-Temperature EBIS

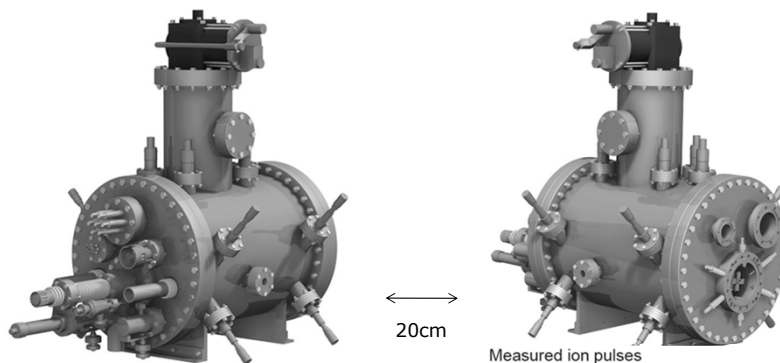


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## Dresden EBIS-SC – A superconducting EBIS



- L-He free at 4.2K
- electron beam energy up to 30 keV
- electron beam current up to 700 mA
- magnetic field on-axis 6T

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Measured ion pulses

| Ion                         | Max. Ions/pulse   | Max. pulse rate/Hz |
|-----------------------------|-------------------|--------------------|
| H <sup>+</sup>              | 3·10 <sup>9</sup> | 500                |
| H <sub>2</sub> <sup>+</sup> | 3·10 <sup>9</sup> | 1000               |
| C <sup>4+</sup>             | 8·10 <sup>8</sup> | 10                 |
| C <sup>6+</sup>             | 4·10 <sup>8</sup> | 10                 |
| Ar <sup>16+</sup>           | 2·10 <sup>7</sup> | 2                  |
| I <sup>43+</sup>            | 1·10 <sup>6</sup> | 1                  |

## Basic Physics of EBIS

The intended purpose of an EBIS is to produce highly charged ions. For a certain ionisation stage  $q$  two opposite processes take place in the electron beam:

### Charge-generating processes

- Ionisation (ion)
- Charge Exchange (ce)
- Radiative Recombination (RR)

### Charge destructive processes

- Ionisation
- Charge Exchange
- Radiative Recombination
- Ion loses from the trap

## Charge Balance of Ions with the Charge State $q$

Rate equations

$$\frac{dn_q}{dt} = n_e v_e \left[ \sigma_{q-1 \rightarrow q}^{ion} n_{q-1} - \left( \sigma_{q \rightarrow q+1}^{ion} + \sigma_{q \rightarrow q-1}^{RR} \right) n_q + \sigma_{q+1 \rightarrow q}^{RR} n_{q+1} \right] - n_0 v_{ion} \left[ \sigma_{q \rightarrow q-1}^{ce} n_q - \sigma_{q+1 \rightarrow q}^{ce} n_{q+1} \right] - f_q^{col} e^{-\frac{qeU_t}{kT_{ion}}} n_q$$

Charge-generating processes (sources for  $A^{q+}$ )

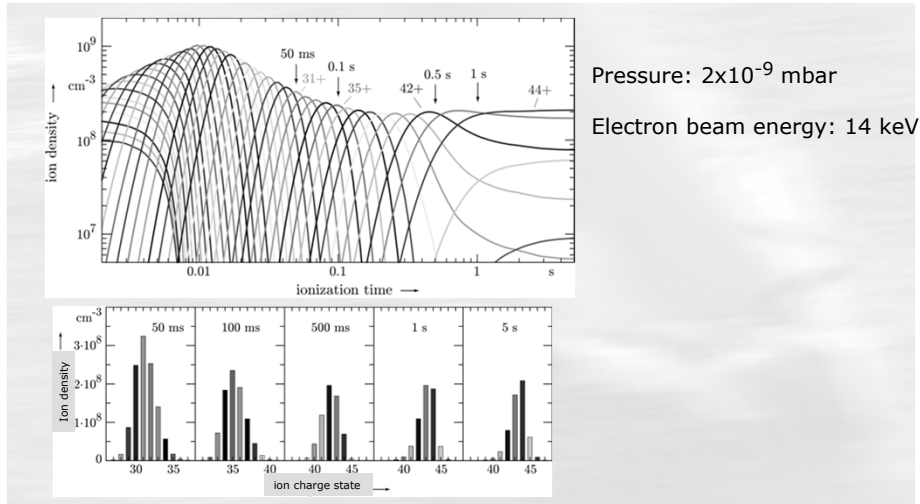
Charge destructive processes (sinks for  $A^{q+}$ )

$U_t$  - depth of the potential wall (radial and axial) trap potential  
 $kT_{ion}$  - ion energy

→ We should consider

- the electron beam energies
- the vacuum in the ionization region
- the excitation functions of individual processes

## Example: Ionization of Xenon in a Dresden EBIS-A



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## Production of HCI - Ionization Factor

The basic process in the electron beam of an EBIS is **successive electron impact ionization** with an average ionization time for the ionization of ions with the charge state  $q$  of

$$\tau_{q \rightarrow q+1} = \frac{n_q}{f_{q \rightarrow q+1}} = \frac{1}{n_e v_e \sigma_{q \rightarrow q+1}} = \frac{e}{j_e \sigma_{q \rightarrow q+1}}$$

with the collision frequency

$$f_{q \rightarrow q+1} = n_e n_q v_e \sigma_{q \rightarrow q+1}$$

This expressions lead to the **ionization factor**

$$j_e \tau_{q \rightarrow q+1} = \frac{e}{\sigma_{q \rightarrow q+1}}$$

i.e. ionization is possible if we have

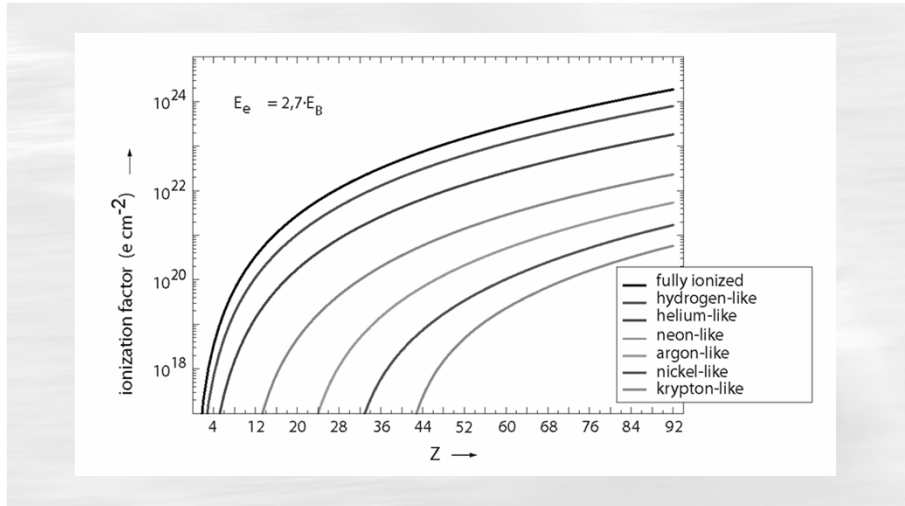
$$j_e \tau_{q \rightarrow q+1} \geq \frac{e}{\sigma_{q \rightarrow q+1}}$$

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# Ionization Factor vs. Atomic Number and Degree of Ionisation

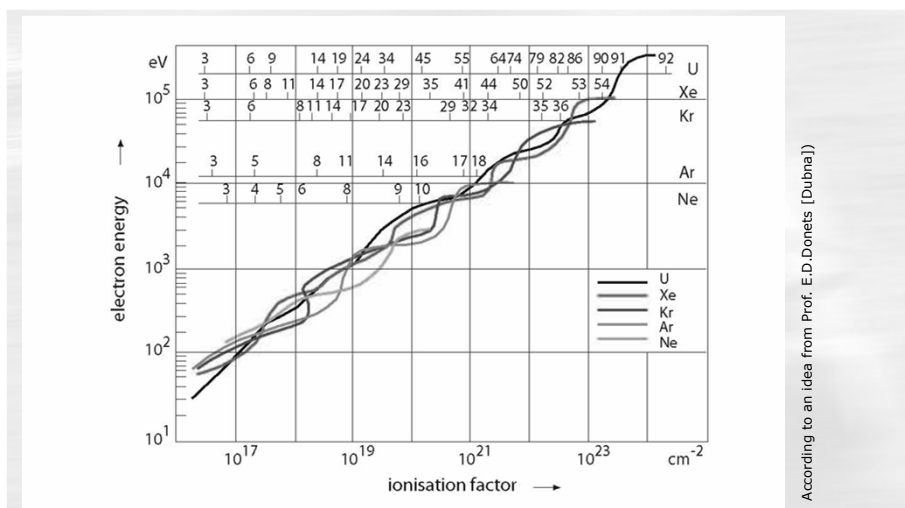


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# Ionization Factor vs. Atomic Number, Degree of Ionization and Electron Energy



According to an idea from Prof. E.D. Donets (Dubna)

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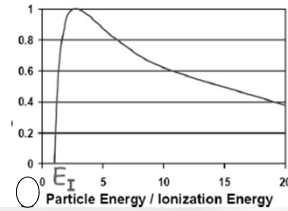
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# Electron Binding Energies

Threshold values for ionization

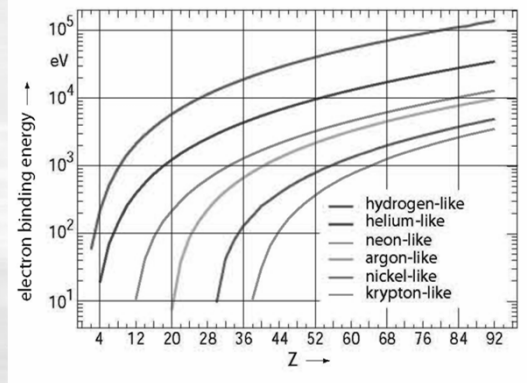


ionization cross section



The optimal energy for ionizing an ion from the charge state  $q$  to  $q+1$  is nearly  $e$ -times the ionization energy of the weakest bound electron.

Ionization starts at the ionization threshold  $E_I$ .



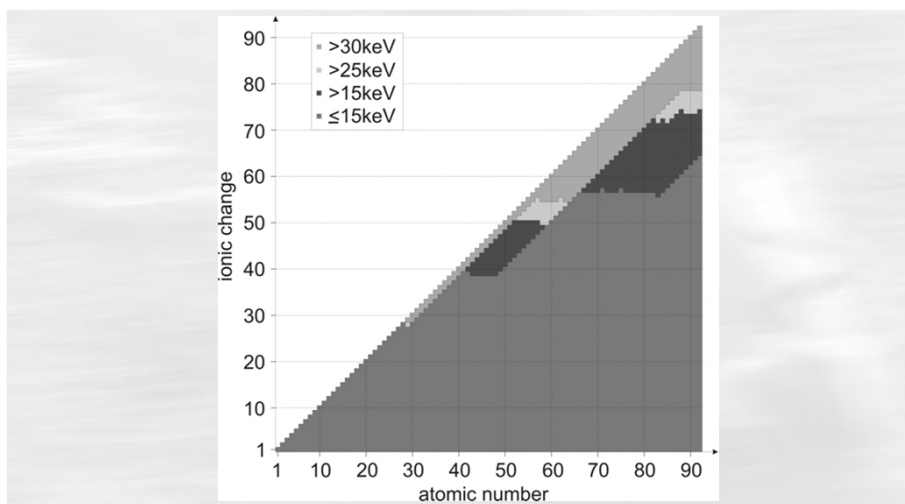
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# Electron Binding Energies

Threshold values for ionization



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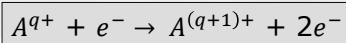
## Basic Physics

Let's have a look onto the most important physical processes in the electron beam:

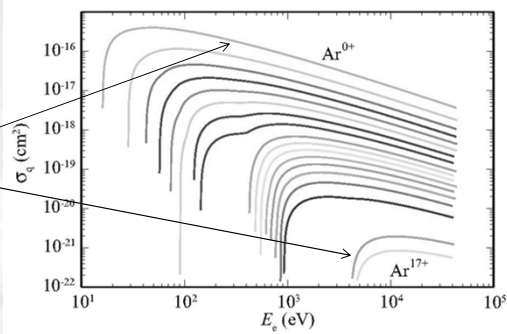
- Single ionization
- Double ionization
- Single charge exchange
- Double charge exchange
- Radiative recombination

## Basic Physics

### Single Electron Impact Ionization



The higher the ion charge state, the smaller is the ionization cross section



$$\sigma_{q \rightarrow q+1} = 4.5 \cdot 10^{-14} \sum_{i=1}^N \frac{\ln \frac{E_e}{E_{nl}}}{E_e \cdot E_{nl}} [cm^2]$$

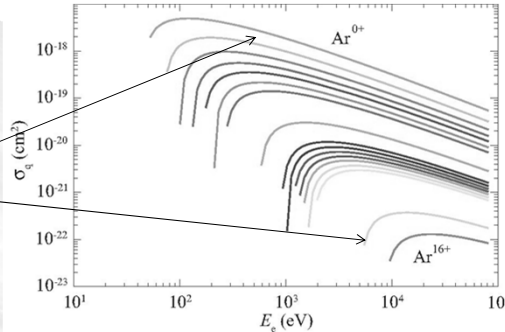
Lotz formula for  $E_e \gg E_{nl}$   
(estimated error: up to 10%;  
N: number of subshells)

# Basic Physics

## Double Electron Impact Ionization



The higher the ion charge state, the smaller is the ionization cross section



Shevelko formula

$$\sigma_{q \rightarrow q+2} = 1.4 \cdot 10^{-19} \frac{N^{1.08}}{\left(\frac{E_q [eV]}{13.6 eV}\right)^2} \left(\frac{U}{U+1}\right)^c \frac{\ln(U+1)}{U+1} [cm^2]$$

with

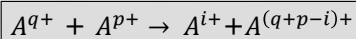
$$U = \frac{E_e}{E_q} - 1$$

c=1 for neutrals and c=0.75 for ions  
 $E_q$  - sum of the ionization potentials of both weakest bound electrons  
 N - number of electrons in the atom/ion

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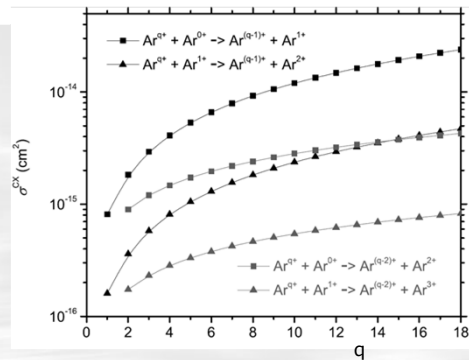
# Basic Physics

## Charge Exchange



Cross sections are independent on the electron energy.

Charge exchange with neutrals is dominant and the main loss process for highly charged ions.



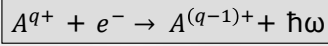
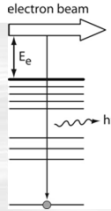
$$\sigma_{q \rightarrow q-1} \approx (1.43 \pm 0.76) \cdot 10^{-12} q^{1.17} (E_q [eV])^{-2.76} [cm^2] \quad \text{Single charge exchange (Müller and Salzborn)}$$

$$\sigma_{q \rightarrow q-2} \approx 1.08 \cdot 10^{-12} q^{0.71} (E_q [eV])^{-2.8} [cm^2] \quad \text{Double charge exchange}$$



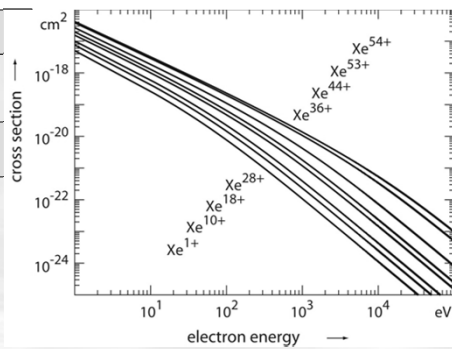
# Basic Physics

## Radiative Recombination (RR)



Charge exchange is strong at low electron energies.

Due to RR processes ionization in an EBIS is more efficient at higher electron energies.



$$\sigma_{q \rightarrow q-1}^{RR} = 2.10 \cdot 10^{-22} \frac{E_0^2}{n E_{cm} (E_0 + n^2 E_{cm})} [cm^2]$$

Theory from Stobbe (for fully ionized atoms)  
 E<sub>0</sub> - binding energy of the hydrogen-like ground-state ion  
 n - main quantum number of the shell where the electron is captured  
 E<sub>cm</sub> - CM collision energy between electrons and ions

$$\sigma_{q \rightarrow q-1}^{RR} = \frac{8\pi}{3\sqrt{2}} \alpha \lambda_c^2 \chi_q(E_e) \ln \left( 1 + \frac{\chi_q(E_e)}{2(n + (1 - W_n) - 0.3)} \right)$$

Theory from Kim and Pratt (for all ions)  
 W<sub>n</sub> - ratio of the number of unoccupied states to the total number of states in the subshell  
 λ<sub>c</sub> - Compton-wavelength

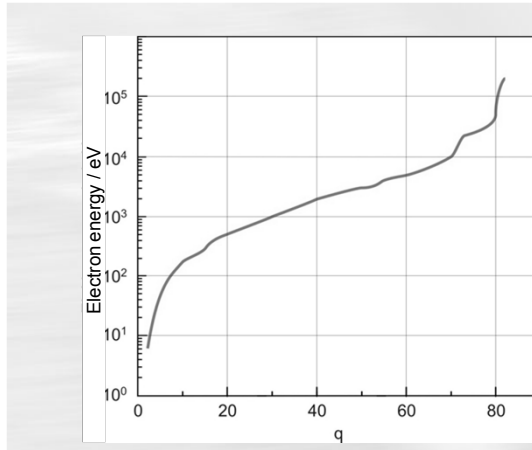
with  $\chi_q(E_e) = (Z + q)^2 \frac{13.6 \text{ eV}}{4E_e}$

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# Basic Physics

## Radiative Recombination (RR)



Balance between ionization and radiative recombination for lead ions  
 (after: R.Becker; ICIS 2009, Gatlinburg)

Ion loss ratio:

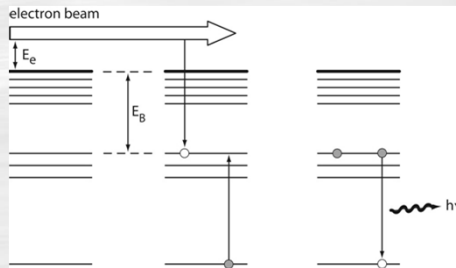
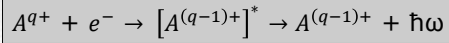
$$R = 2 \cdot 10^{-13} n_e [cm]^{-3} \frac{q^2}{\sqrt{E_e [eV]}} \left[ \frac{cm^3}{s} \right]$$

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## Basic Physics

### Dielectronic Recombination (DR)



Capture of an electron from the continuum at simultaneous excitation of a second electron and following deexcitation (photon emission).

$$R_{DR} = 6 \cdot 10^{-10} N \left( \frac{q}{E_e} \right)^{\frac{3}{2}} \sqrt{E_q} e^{-\frac{E_q}{E_e}} \left[ \frac{cm^3}{s} \right]$$

$N$  - number of electrons in the outermost occupied shell  
 $E_q$  - ionization energy of the ion with the charge  $q$

Ion loss ratio

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## EBIS: Basic Properties

### Electrical trap capacity

The total number of ions stored in an EBIS is determined by the electrical trap capacity  $C_{el}$ .

#### Assumption:

Homogeneous electron beam passing an ion trap of the **length L** with an **electron beam current  $I_e$** . The **electron energy** is  **$E_e$** .

With

$$I_e = \frac{dQ}{dt}, v_e = \frac{dx}{dt}, v_e = \sqrt{\frac{2E_e}{m_e}} \iff \Delta Q = \frac{I_e \Delta x}{v_e} = \frac{I_e L}{\sqrt{\frac{2E_e}{m_e}}}$$

follows

$$C_{el} = 1.05 \cdot 10^{13} \frac{I_e [A] L [m]}{\sqrt{E_e [eV]}}$$

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# EBIS: Basic Properties

## Electrical trap capacity

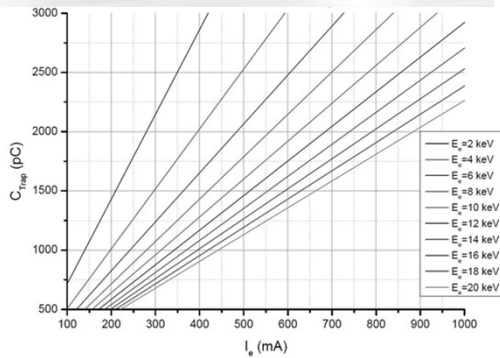


$$C_{el} = 1.05 \cdot 10^{13} \frac{I_e [A] L [m]}{\sqrt{E_e [eV]}} \cdot f \cdot \alpha$$

For practical purposes we must consider

- the charge compensation  $f$  ( $f < 1$ ) of the electron beam,
- the fraction  $\alpha$  of ions with a certain ion charge state in the ion charge state spectrum of the produced ions.

**Example:**  
Trap capacity of the Dresden EBIS-SC at different electron beam currents and different electron beam energies.



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# EBIS: Basic Properties

## Electron beam: space charge potential



### Radial trap potential

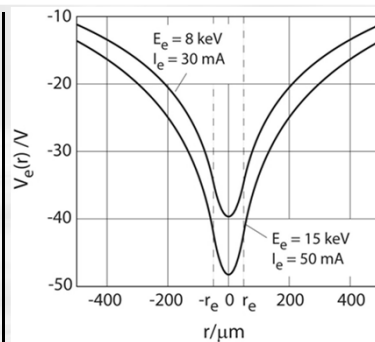
$$V_e(r) = \begin{cases} U_e \left(\frac{r}{r_e}\right)^2 & \text{für } r < r_e \\ U_e \left(2 \ln \frac{r}{r_e} + 1\right) & \text{für } r > r_e \end{cases}$$

with

$$U_e = \frac{I_e}{4\pi\epsilon_0 v_e} = \frac{1}{4\pi\epsilon_0} \cdot \sqrt{\frac{m_e}{2}} \frac{I_e}{\sqrt{E_e}}$$

For estimations we get:

$$U_e = \frac{30 I [A]}{\sqrt{1 - \left(\frac{E_e [keV]}{511} + 1\right)^{-2}}} [V]$$



### Example:

Radial trap potentials in a Dresden EBIT.

The potential of the drift tubes is superimposed by  $U_e$  in the center of the electron beam.

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## EBIS: Basic Properties

Electron beam: equation of motion and beam radius



Equation of motion for r

$$\frac{d^2r}{dt^2} = \frac{eI_e}{2\pi\epsilon_0 v_z r m_e} + \frac{e^2}{4m_e^2} \left( \frac{B_c^2 r_c^4}{r^3} - B_z^2 r \right)$$

$B_c$  - B-field at the cathode

$r_c$  - cathode radius

Assuming  $B_c = 0$  exists a stationary solution of the above equation. The solution corresponds to an equilibrium flow of the electrons with constant radius, the so-called Brillouin-Flow.

We obtain:

$$B = B_B = \frac{1}{r} \left( \frac{2I_e m_e}{\pi \epsilon_0 v_z |e|} \right)^{1/2} \quad \text{and} \quad r_B = \frac{1}{B_B} \left( \frac{2I_e m_e}{\pi \epsilon_0 v_z |e|} \right)^{1/2}$$

For a Brillouin flow all electrons have a constant distance to the beam center. Thereby the Lorentz force caused by the magnetic field is compensated by the space charge and the centrifugal force of the rotating electrons.

## EBIS: Basic Properties

Electron beam: beam radius and Herrmann theory \*



Electron beam dynamics, considering

- a magnetic field at the cathode,
- thermal effects at the cathode due to filament heating up to the temperature  $T_c$ ,
- interactions between the electrons

lead to a corrected electron beam radius (smaller than  $r_B$ )

→ Herrmann Theory

\* (G.Herrmann; J.Appl.Phys., 29 (1958) 127)

## EBIS: Basic Properties

Electron beam: beam radius and Herrmann theory\*

Electron beam radius, enclosing 80% of the beam

$$r_e = r(0) \cdot \sqrt{\left(1 - \frac{r_0}{r(0)}\right)^2 + \frac{2}{1 + \frac{B_C^2 r_C^4}{B_Z^2 r_0^4}} \left(\frac{v_e \tan \gamma}{\frac{e}{m_e} B_Z} \gamma\right)}$$

and

$$r_0 = r_B \left( \frac{1}{2} + \frac{1}{2} \left[ 1 + 4 \left( \frac{8kT_C r_C^2 m_e}{e^2 B_Z^2 r_B^4} + \frac{B_C^2 r_C^4}{B_Z^2 r_B^4} \right)^{1/2} \right] \right)^{1/2}$$

with

$r(0)$  - beam radius at the cathode

$\gamma$  - angle deviation from the source axis

\* (G.Herrmann; J.Appl.Phys., 29 (1958) 127)

## EBIS: Basic Properties

Electron beam: experimental results

- Electron beam density determines the ionization rate → investigation necessary for understanding the ionization process

Generally:  
electron beam diameter

**(40...200) μm**

- Dresden EBIT:

$$r_{80\%} = 89 \pm 4 \mu\text{m}; j_e = 96 \pm 9 \text{ A/cm}^2$$

$$\text{@ } E_e = 7.8 \text{ keV}; I_e = 30 \text{ mA}$$



e- beam aperture CCD

CCD image



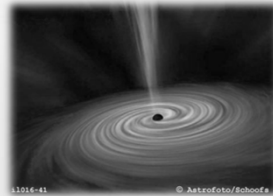
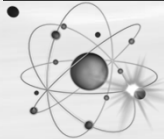
# Electron Beam Ion Sources

Production of HCI



Electron-impact ionization:  
It is hot in the ion trap

> 100.000.000 K



Conditions as at the border of a black hole ...

The electron beam energy of an EBIS  
can be adjusted with a precision of eV

→ Selective excitation and preparation  
of atomic states and ion charge states



Electron beam scalpel

Folie 43  
G.Zschornack  
Röntgenspektroskopie an hochgeladenen Ionen

TU Dresden,  
11.05.2012

# EBIS: Basic Properties



ion beam  
properties

pulse form  
and width

emittance

energy  
spread

extracted  
ions  
(see later)

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Seite 44

May 12

# EBIS/T – Operation Modes

Three operation modes:

## 1. Permanently opened trap – transmission mode

The trap is permanently open and ions are produced in the electron beam without axial trapping.

This mode delivers high currents of the lowest charged ions (nA ... μA).

## 2. Partially closed trap – leaky mode

Selecting a low axial potential wall a certain amount of ions with adequate kinetic energy can surpass the potential wall and are extracted continuously.

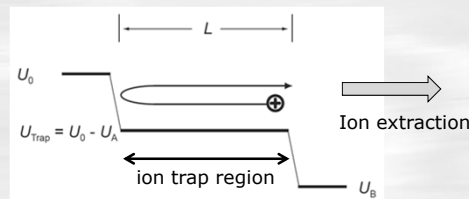
This mode delivers ions with preferently low up to intermediate ion charge states (up to nA) and a low fraction of higher ion charge states.

## 3. Periodically opened and closed trap – pulsed mode

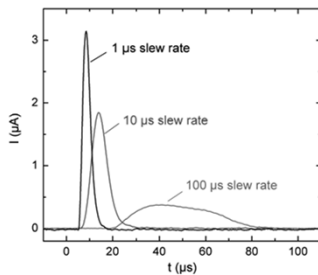
The potential wall is high enough to trap all ions axially. Periodical opening of the trap releases pulses of ions extracted with typical pulse lengths in the order of some microseconds and allow to produce highest currents of highly charged ions (up to μA per pulse).

# Particularities of EBIT/EBIS puls form – classical extraction

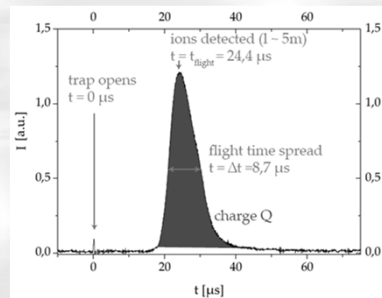
FWHM is in the order of μs



Ion paths in the moment of ion extraction



Ion pulses from the Dresden EBIS-A  
Trap length – 6 cm



## Particularities of EBIT/EBIS puls form – ns ion extraction

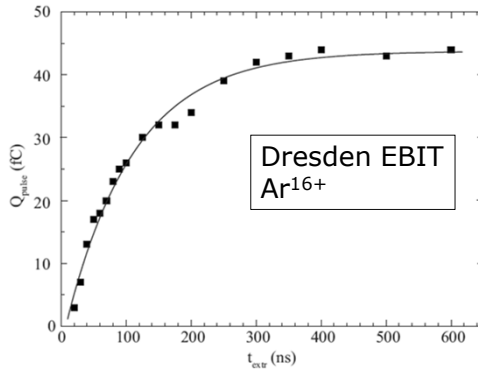


FIG. 3. Extracted ionic charges per Ar<sup>16+</sup> pulse in dependence on the extraction time  $t_{\text{extr}}$  ( $U_0=4.0$  kV,  $I_e=24$  mA,  $t_{\text{cyc}}=100$   $\mu$ s,  $t_{\text{wait}}=1$  s,  $p=3.1 \times 10^{-9}$  mbar). The solid line is a guide to the eye.

REVIEW OF SCIENTIFIC INSTRUMENTS 81, 02A507 (2010)

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Short time ion pulse extraction from the Dresden electron beam ion trap<sup>9)</sup>

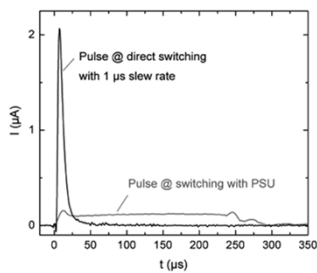
11. Mai 2012

U. Kentsch,<sup>1</sup> G. Zschornack,<sup>2,3)</sup> A. Schwan,<sup>1</sup> and F. Ullmann<sup>1</sup>

<sup>1</sup>Drebit GmbH, D-01109 Dresden, Germany

<sup>2</sup>Institute of Applied Physics, Dresden University of Technology, D-01062 Dresden, Germany

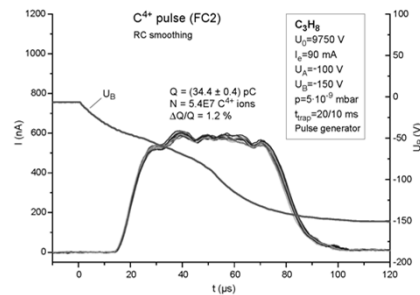
## Particularities of EBIT/EBIS puls form – flat top pulses



Proton pulse from the Dresden EBIS-A after direct trap opening and after switching with the PSU forming a flat-top pulse shape

One of the requirements for the applications of EBIS with synchrotrons are flat-top pulses.

Controlling properly  $U_B$  flat-top pulses with FWHM to at least 100  $\mu$ s can be formed.

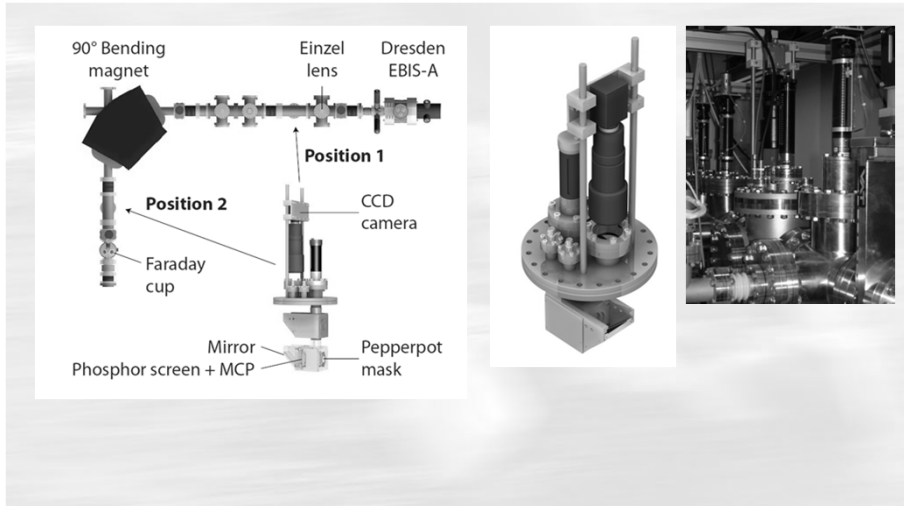


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# Particularities of EBIT/EBIS Emittance

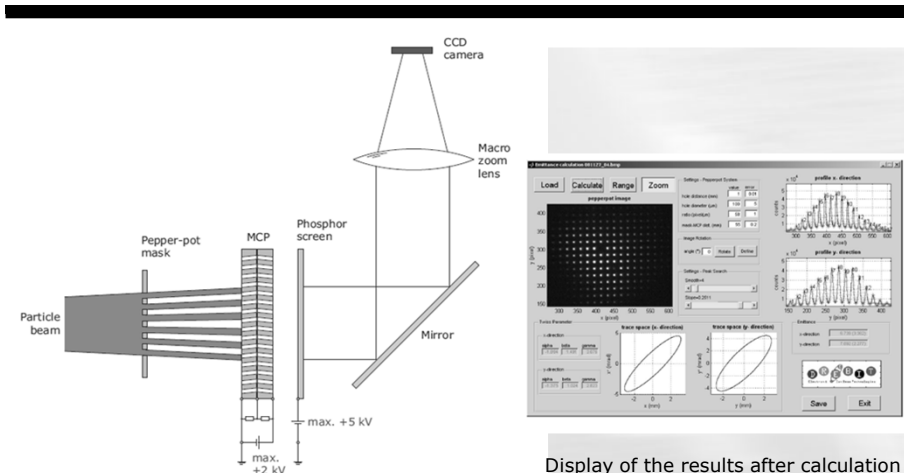


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# Particularities of EBIT/EBIS Emittance



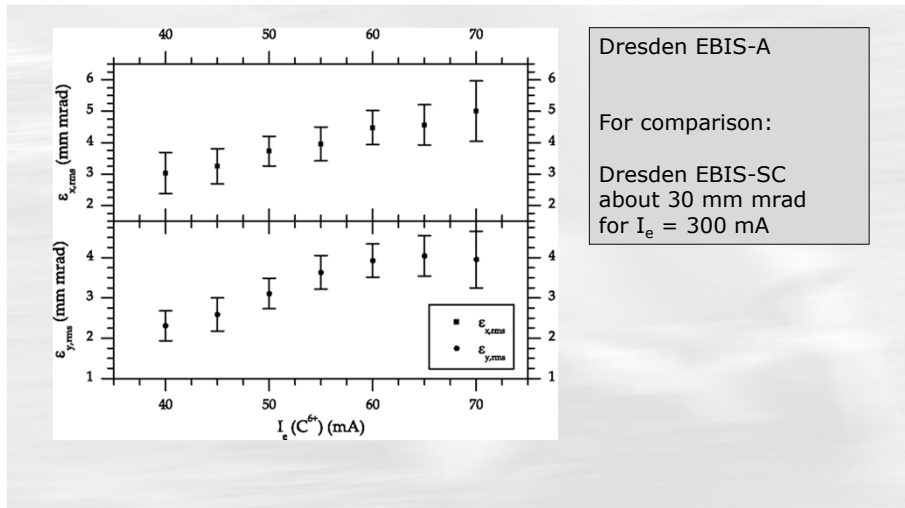
Display of the results after calculation

The scheme of the Pepper-Pot Emittance Meter is pictured in figure 2. The incoming particle beam passes the Pepper-Pot mask and is separated into several beam spots. The particles hitting the MCP create an electron current which is amplified passing the two micro channel plates. The electrons are then accelerated towards the phosphor screen. The visible light spots created at the phosphor screen are detected after 90° deflection by a CCD camera.

The emittance of the beam can be determined from the position, the size, and the shape of the light spots.

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## Particularities of EBIT/EBIS Emittance

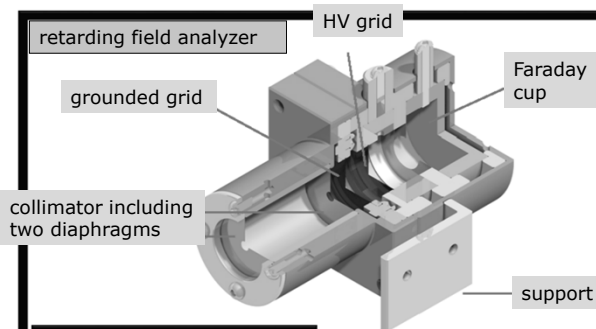


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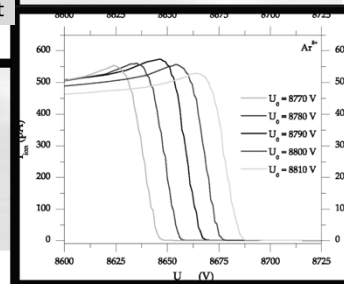
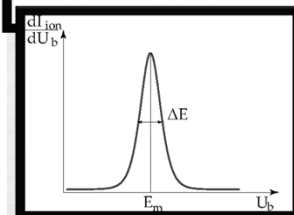
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## Particularities of EBIT/EBIS Energy spread



The differentiation of the measured curves gives

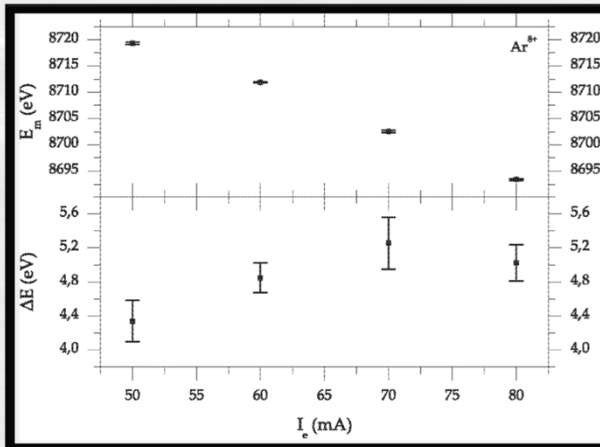
- The energy spread
- The total beam energy of the analyzed ion beam.



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## Particularities of EBIT/EBIS Energy spread

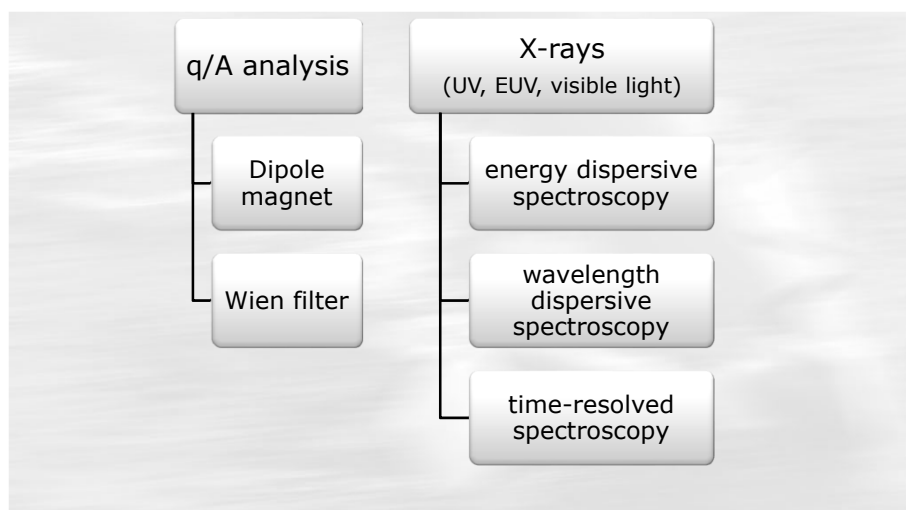


Dresden EBIS-A Ar<sup>8+</sup>

Total ion beam energy  
(shifts due to different  
depths of the beam  
Coulomb potential)

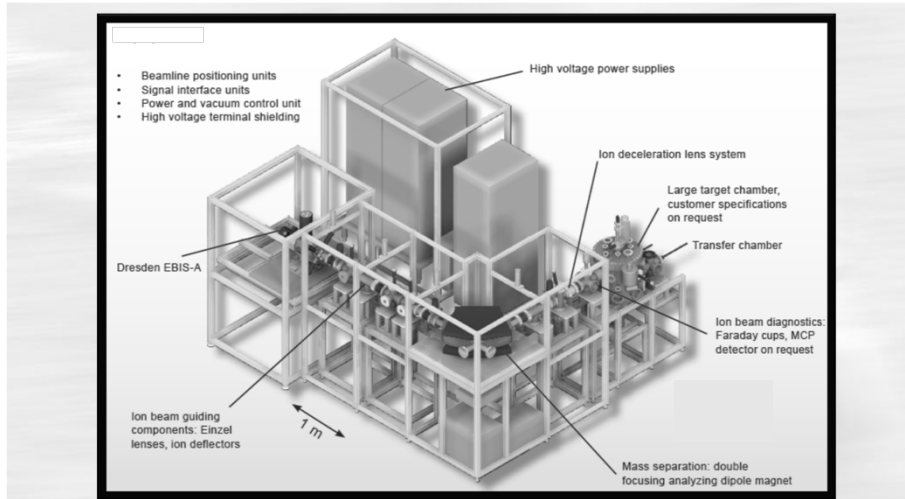
Energy spread of Ar<sup>8+</sup>  
(the energy spread is  
below 1 eV/u in any case)

## EBIS: Diagnostics Processes in the ion source



# EBIS: Diagnostics

## q/A Analysis



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# q/A analysis: dipole magnet



Objective: charge state separated ion beam

Lorentz force = centripetal force

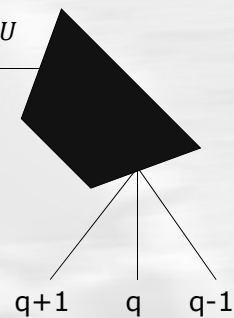
$$E_{kin} = q \cdot U$$

$$q \cdot v \cdot B = \frac{mv^2}{r}$$

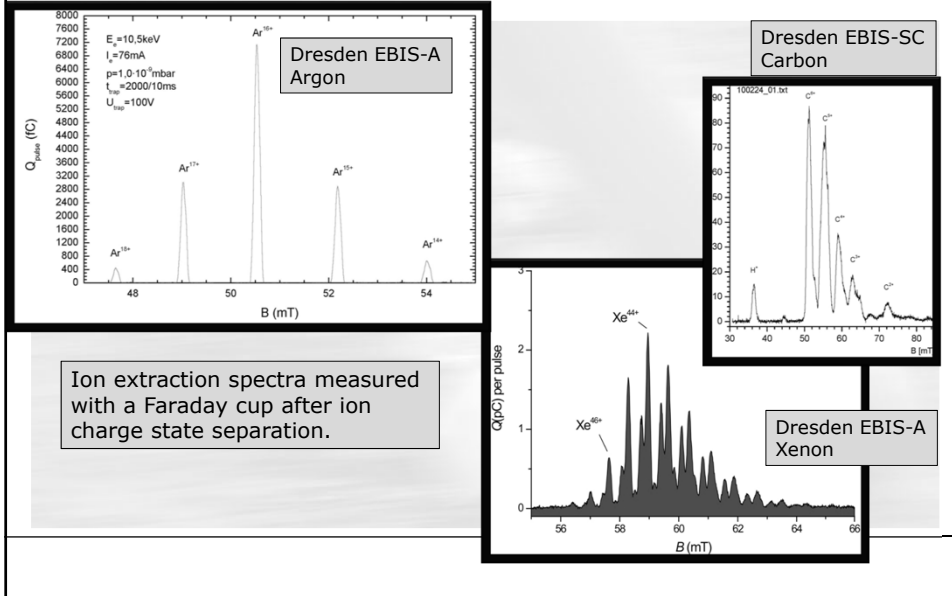
- Ion charge state separation

$$\frac{q}{A} = \frac{2 \cdot U}{r^2 B^2}$$

dipole magnet



## q/A analysis: dipole magnet Examples for ion charge state spectra

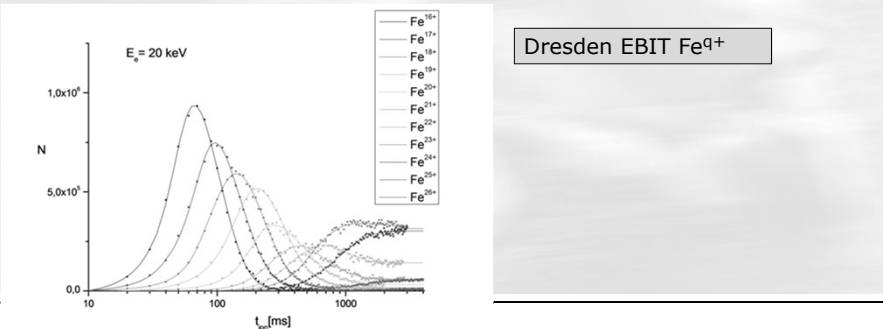


## q/A analysis: dipole magnet time-resolved ion charge state spectra

Signal intensity of individual ion charge states measured at different ionization times → reveals the evolution of charge states in the trap

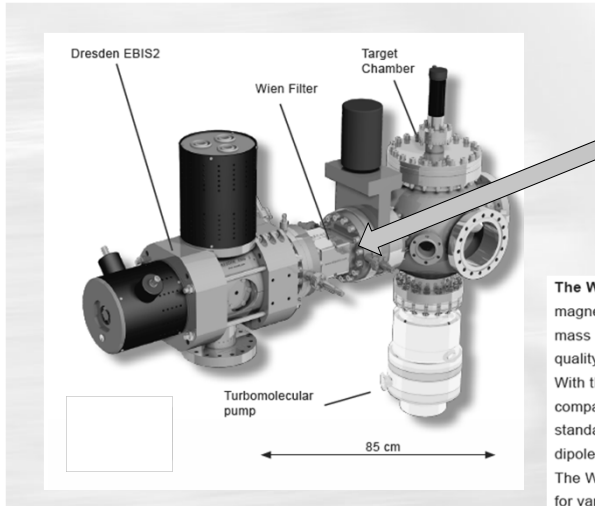
Further analysis allows for

- characterizing the charge balance inside the trap
- estimating the ionisation factor of the source
- determining electron impact ionisation cross sections.



# EBIS: Diagnostics

## q/A Analysis with a Wien filter



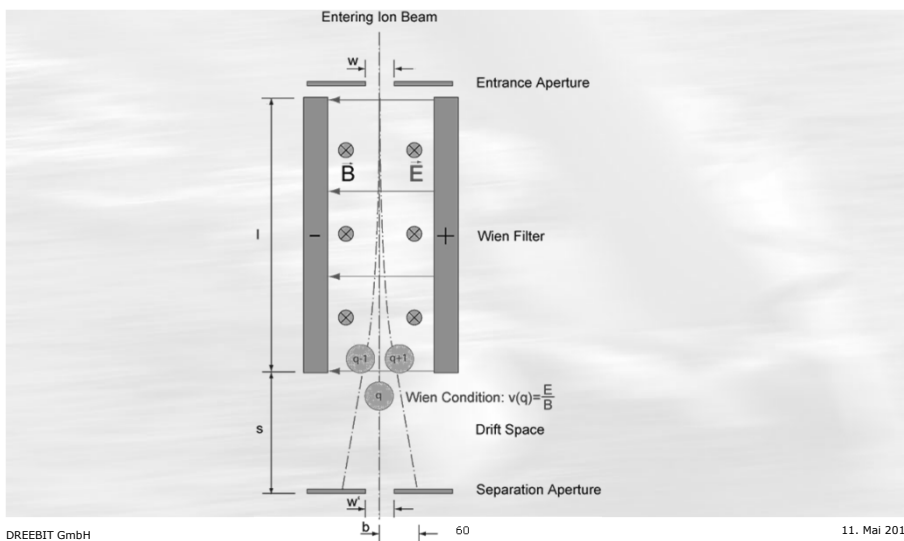
The Wien Filter is a particle separator with a crossed magnetic and electric field configuration providing mass and charge state separated beams of excellent quality at small spatial dimensions (15cmx20cmx20cm). With the Wien filter as an ion source add-on a very compact device is available substituting a complete standard beamline setup with a space consuming dipole magnet and other necessary equipment. The Wien filter can be used as stand-alone solution for various beam line setups. In dependence on the installed mass- and charge state-separating aperture a resolution of better than 80 is available.

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# EBIS: Diagnostics

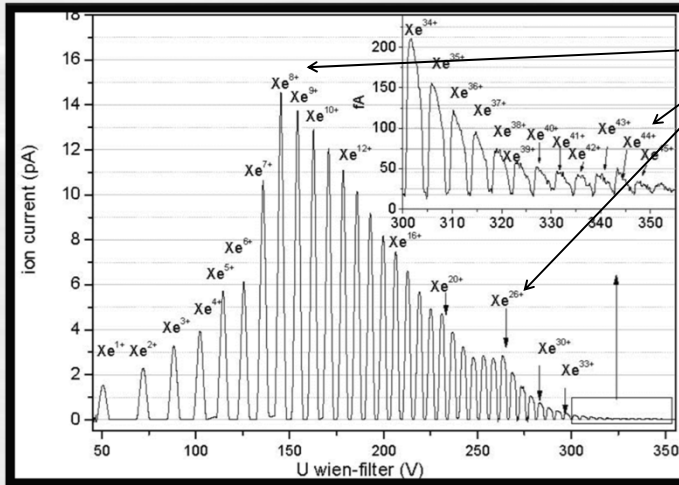
## q/A Analysis with a Wien filter



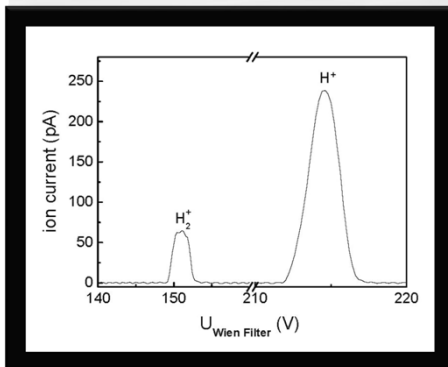
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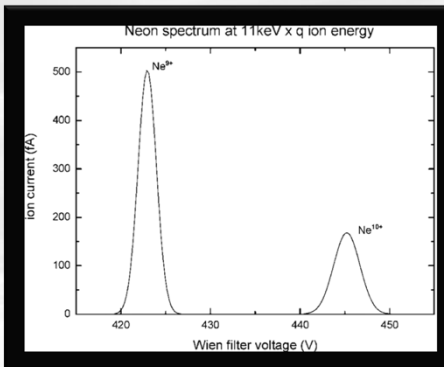
q/A analysis: Wien filter  
Examples for ion charge state spectra



q/A analysis: Wien filter  
Examples for ion charge state spectra



Dresden EBIT  
Hydrogen



Dresden EBIT  
Neon

## DREEBIT Ion Sources

Pulsed mode



### Pulsed mode (ions/pulse)

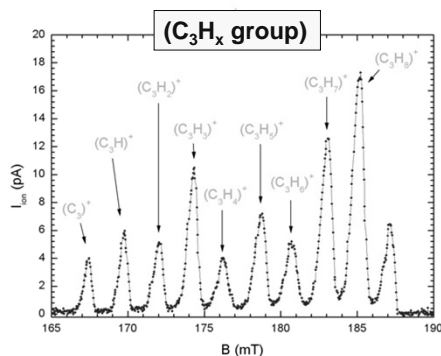
| Ion                     | EBIT       | EBIS-A     | EBIS-SC     | EBIT:EBIS-A:EBIS-SC  |
|-------------------------|------------|------------|-------------|----------------------|
| <b>C<sup>4+</sup></b>   | 24.000.000 | 80.000.000 | 900.000.000 | 1 : 3 : <b>38</b>    |
| <b>C<sup>6+</sup></b>   | 10.000.000 | 30.000.000 | 400.000.000 | 1 : 3 : <b>40</b>    |
| <b>Ar<sup>16+</sup></b> | 900.000    | 7.800.000  | 250.000.000 | 1 : 9 : <b>278</b>   |
| <b>Ar<sup>17+</sup></b> | 45.000     | 1.400.000  | 22.000.000  | 1 : 31 : <b>489</b>  |
| <b>Ar<sup>18+</sup></b> | 6.000      | 90.000     | 1.500.000   | 1 : 15 : <b>250</b>  |
| <b>Xe<sup>44+</sup></b> | 10.000     | 700.000    | 10.000.000  | 1 : 70 : <b>1000</b> |

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## Beams of molecular fragments



Propane C<sub>3</sub>H<sub>8</sub>

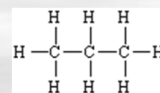
Extraction of all  
molecular fragments

C<sub>x</sub>H<sub>y</sub>

x = 1...3

y = 1...9

y = 9: protonation



A unique possibility to form beams of exotic molecular fragments

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## EBIS: X-Ray Diagnostics X-ray output from EBIS

For an x-ray detector the following count rate can be expected

$$\dot{N}_q = \varepsilon \frac{\Omega}{4\pi} V j_e \omega_q n_q \sigma_q^{exc}$$

$$\dot{N}_q = \varepsilon \frac{\Omega}{4\pi} l l_e \omega_q n_q \sigma_q^{exc}$$

with

- $\varepsilon$  - detector efficiency
- $\Omega/4\pi$  - solid angle
- $V$  - apparent beam volume
- $L$  - apparent beam length
- $\omega_q$  - x-ray fluorescence yield
- $n_q$  - number of ions with the charge  $q$
- $E_{if}$  - transition energy
- $\Sigma_q^{exc}$  - excitation cross section

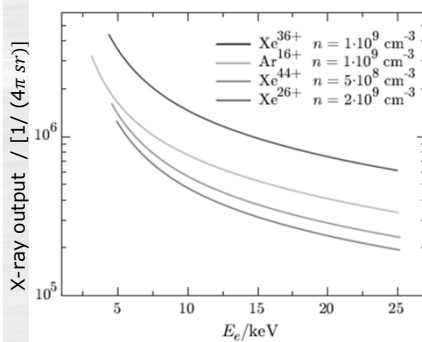
The emitted radiation power can be estimated as

$$P = \dot{N}_q E_{if} e$$

For individual dipole lines radiation power on the order of nW was recorded

## EBIS: X-Ray Diagnostics X-ray output

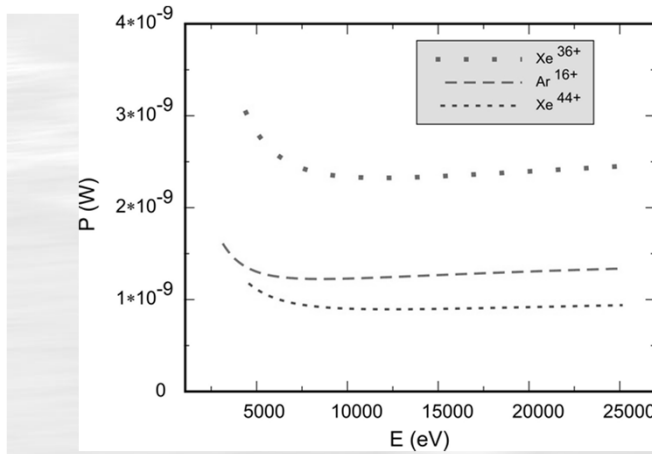
EBIS are excellent sources of X-rays from highly charged ions.



| ion               | transition $i \rightarrow f$  | $E_{if}/\text{eV}$ | $A_{if}/\text{eV/h}$ |
|-------------------|---|--------------------|----------------------|
| Ar <sup>16+</sup> | 2p( <sup>1</sup> P <sub>1</sub> ) → 1s( <sup>1</sup> S <sub>0</sub> ) | 3138,8             | 0,073                |
| Xe <sup>26+</sup> | 3d( <sup>1</sup> P <sub>1</sub> ) → 2p( <sup>1</sup> D <sub>2</sub> ) | 4159.6             | 0.208                |
| Xe <sup>36+</sup> | 3d( <sup>1</sup> P <sub>1</sub> ) → 2p( <sup>1</sup> S <sub>0</sub> ) | 4366.8             | 0.372                |
| Xe <sup>44+</sup> | 3d( <sup>1</sup> P <sub>1</sub> ) → 2p( <sup>1</sup> S <sub>0</sub> ) | 4558.0             | 0.321                |

X-ray output from the Dresden EBIT

## X-rays from highly charged ions radiation power of the Dresden EBIT



The graph shows the most dominant dipole transitions for DE in case of 3 different ion species

EBIS-A: × 10

EBIS-SC: × 200

→ higher transition power

$$P[W] = \frac{\text{photons}}{s} E[eV] e[As]$$

## Z-dependence allowed and forbidden transitions HFS, QED, parity violation

|                            |                 |
|----------------------------|-----------------|
| E1 ( $\Delta n = 0$ )      | Z               |
| E1 ( $\Delta n \neq 0$ )   | Z <sup>4</sup>  |
| M1 ( $\Delta n = 0$ )      | Z <sup>3</sup>  |
| M1 ( $\Delta n \neq 0$ )   | Z <sup>6</sup>  |
| M1 (within fine structure) | Z <sup>12</sup> |
| E2 ( $\Delta n = 0$ )      | Z               |
| E2 ( $\Delta n \neq 0$ )   | Z <sup>6</sup>  |
| E2 (within fine structure) | Z <sup>16</sup> |
| 2E1                        | Z <sup>6</sup>  |
| E1M1                       | Z <sup>6</sup>  |
| Hyperfine splitting        | Z <sup>3</sup>  |
| QED effects                | Z <sup>4</sup>  |
| E <sub>SO</sub>            | Z <sup>4</sup>  |
| Parity violation           | Z <sup>5</sup>  |

Table III. The Z-dependence of the probabilities of allowed and forbidden transitions, hyperfine interaction, QED effect, relativistic effects and parity violation effect along the Hydrogen iso-electronic sequence.

With higher atomic number the intensity of otherwise weak transitions increases.

For highly charged ions otherwise forbidden transitions can become dominant.

Physica Scripta. Vol. T120, 47-52, 2005

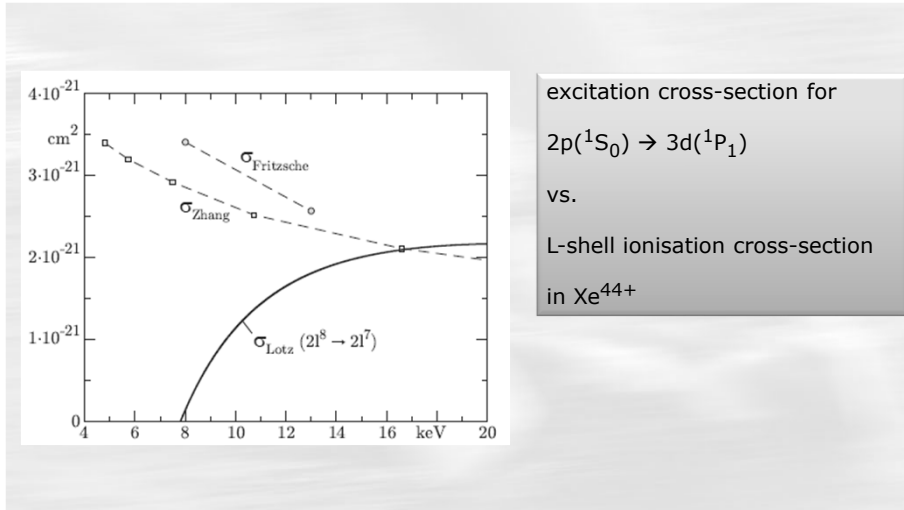
### Physics Based on Electron Beam Ion Traps\*

Yaming Zou<sup>1,2</sup> and Roger Hutton<sup>3</sup>

<sup>1</sup>The Key Lab of Applied Ion Beam Physics, The Ministry of Education, China  
Modern Physics Institute, Fudan University, Shanghai 200433, China

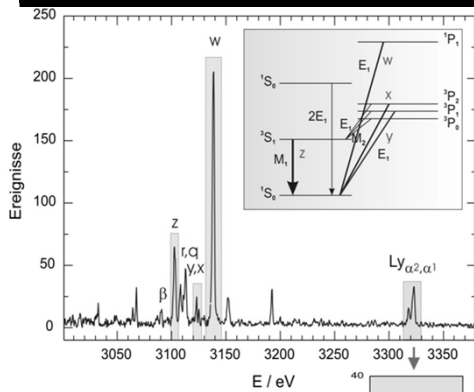
<sup>3</sup>Astronomy Department, Lund University, BOX 43, SE 221 00 Lund, Sweden

# X-rays: excitation vs. ionisation



excitation cross-section for  $2p(^1S_0) \rightarrow 3d(^1P_1)$   
vs.  
L-shell ionisation cross-section in  $Xe^{44+}$

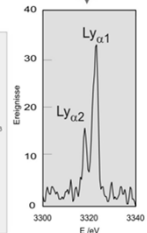
# Wavelength X-ray spectroscopy: Argon



Transition energies in one- and two-electron systems can be calculated very precisely.

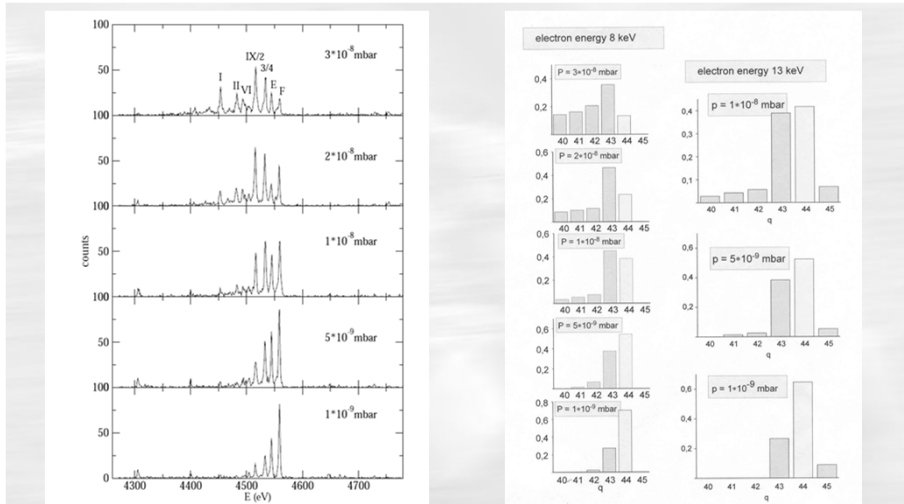
Therefore hydrogen-like ions are excellent sources for well known x-ray transitions: **Lyman lines**

- Ar<sup>16+</sup>: w  $2p(^1P_1) - 1s(^1S_0)$  E = 3139,6(0,25) eV
- z  $2s(^2S_{1/2}) - 1s(^1S_0)$
- y  $2p_{1/2}(^2P_{1/2}) - 1s(^1S_0)$  E = 3123,6(0,25) eV
- x  $2p_{3/2}(^2P_{3/2}) - 1s(^1S_0)$  E = 3126,4(0,4) eV
- Ar<sup>15+</sup>: q  $1s2p(^3P)2s(^2P_{3/2}) - 1s^22s(^2S_{1/2})$
- r  $1s2p(^3P)2s(^2P_{1/2}) - 1s^22s(^2S_{1/2})$
- Ar<sup>14+</sup>: beta  $2p(^1P_1) - 1s(^1S_0)$



an hochgeladenen Ionen

# Wavelength X-ray spectroscopy: Xenon

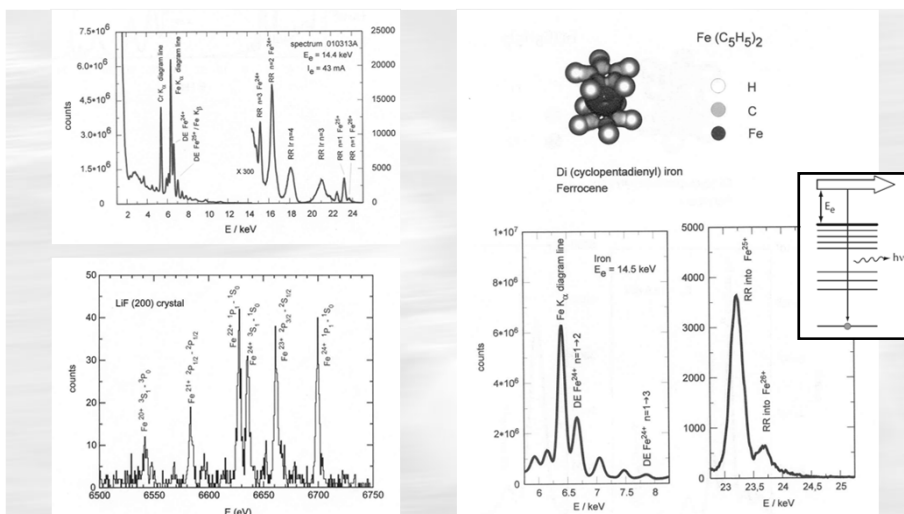


E: 3s - 2p  
F: 3d - 2p

Folie 71  
G.Zschornack  
Röntgenspektroskopie an hochgeladenen Ionen

TU Dresden,  
11.05.2012

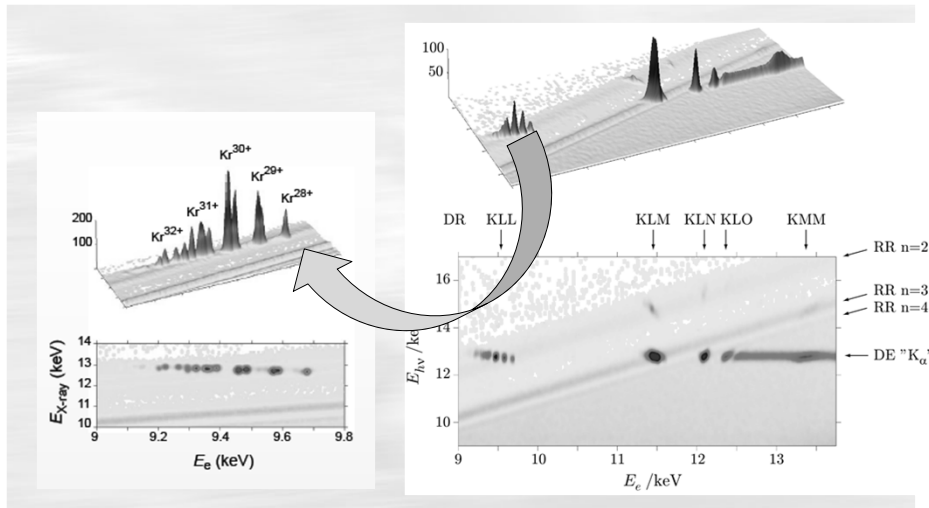
# Energy and Wavelength X-ray spectroscopy: Iron



Folie 72  
G.Zschornack  
Röntgenspektroskopie an hochgeladenen Ionen

TU Dresden,  
11.05.2012

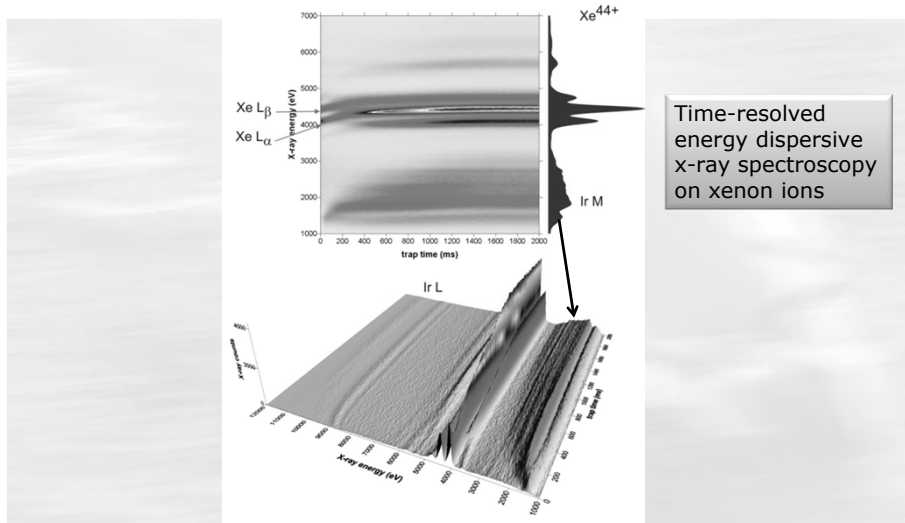
# X-Ray Spectroscopy: Scatterplot



Folie 73  
G.Zschornack  
Röntgenspektroskopie an hochgeladenen Ionen

TU Dresden,  
11.05.2012

# Time-resolved x-ray spectroscopy



Time-resolved energy dispersive x-ray spectroscopy on xenon ions

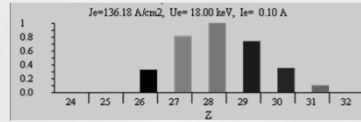
Folie 74  
G.Zschornack  
Röntgenspektroskopie an hochgeladenen Ionen

TU Dresden,  
11.05.2012

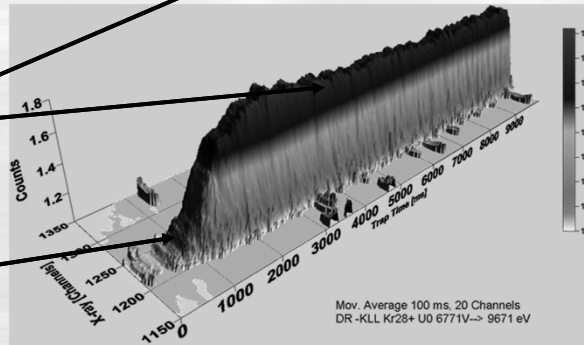
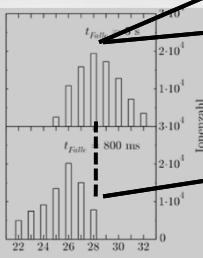
## Time-resolved KKL-DE x-ray spectroscopy

KLL Kr<sup>28+</sup>

(fixed electron beam energy,  
but x-rays as a function of the ionization time)



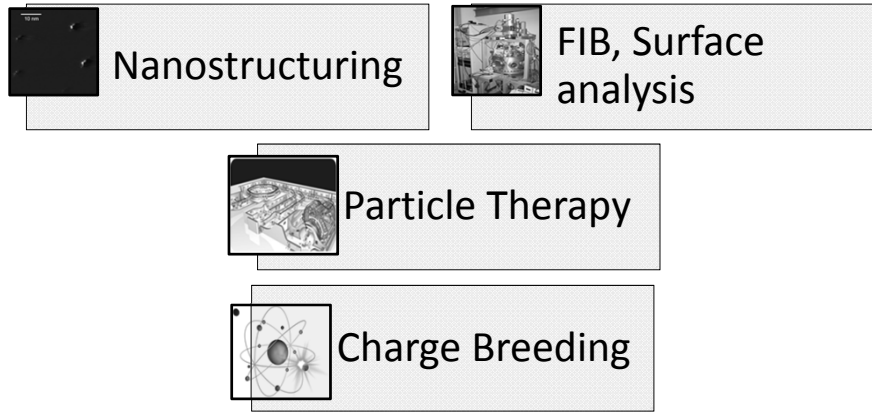
results of ion extraction



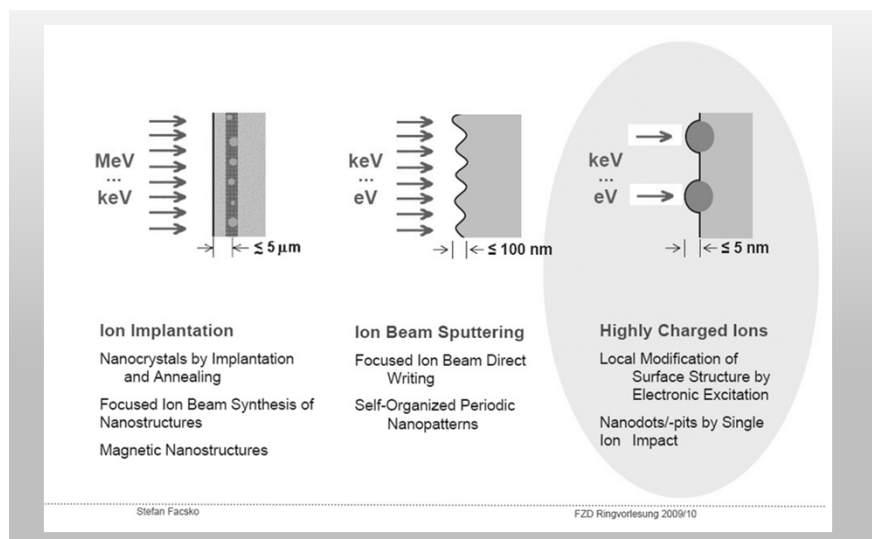
## Applications of highly charged ions (examples)



# Applications of highly charged ions (examples)

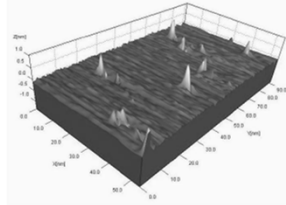


# Nanostructuring with highly charged ions



# Nanostructuring with HCI

## Surface Modifications Induced by Potential Energy



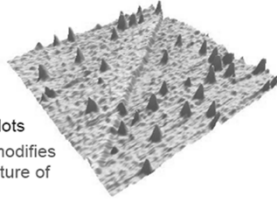
HOPG, 150 eV Ar<sup>9+</sup>, E<sub>pot</sub> = 1000 eV

### HOPG

- Conductor
  - AFM: flat surface
  - STM: nanodots
- HCI impact modifies *electronic* structure of surface

### CaF<sub>2</sub>

- Insulator
  - AFM: nanodots
- HCI impact modifies *crystal* structure of surface

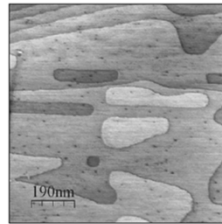


CaF<sub>2</sub>, 5.4 keV Xe<sup>36+</sup>, E<sub>pot</sub> = 27.8 keV

Stefan Facsko

### KBr

- Insulator
  - Nanopits
- HCI impact induces desorption



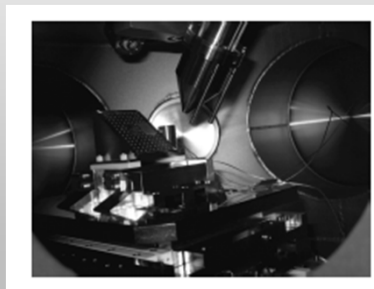
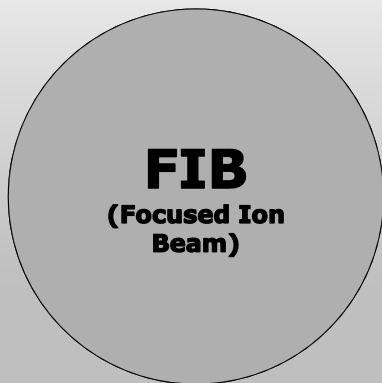
KBr, Xe<sup>34+</sup>, 24 keV, E<sub>pot</sub> = 20 keV

FZD Ringvorlesung 2009/10

## New properties:

- morphologic
- electric
- optic

# Focussed Ion Beams



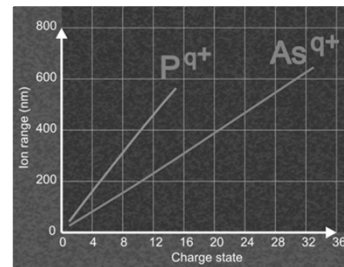


## A new class of FIB

| Feature       | New Advantage   |
|---------------|---|
| Projectiles   | Almost all elements of the periodic table, in particular noble gases    |
| Charge State  | Free choice of projectile charge state                                  |
| Sputter Yield | Variable, according to the kinetic and potential energy                 |
| Implantation  | Variable implantation depth, according to the kinetic projectile energy |

### **Implantation in Si:**

Realization of different implantation depths due to different ion charge states at a fixed ion acceleration potential



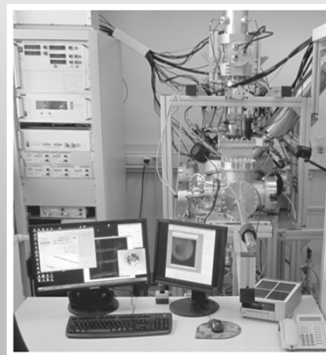
## A new class of FIB

By using DREEBIT ion sources

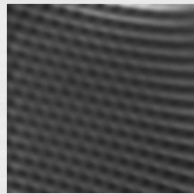
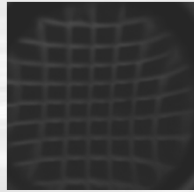
Production of ion beams with different ion charge states with diameters in the micrometre up to nanometre region.

### Applications

|                            |
|----------------------------|
| Lithography                |
| Nano Engineering           |
| Photonic Structures        |
| Materials Characterization |
| Micro-Machining            |
| Quantum Dots               |
| Radiation Biology          |
| Surface Analytics          |



# Xe - FIB

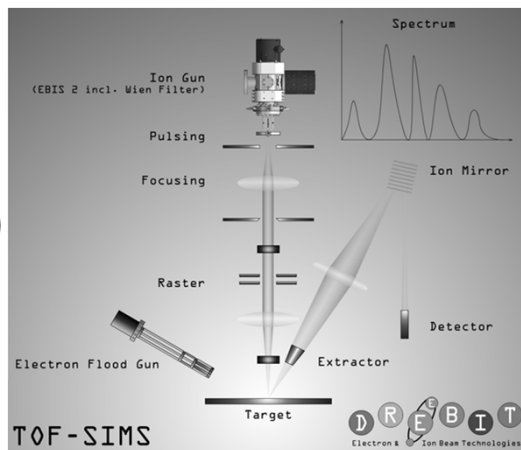


Worldwide first SEM-figures produced with a Xe ion beam!

lattice width 2  $\mu\text{m}$

# Time-of-Flight Secondary Ion mass Spectrometry

**TOF-SIMS**



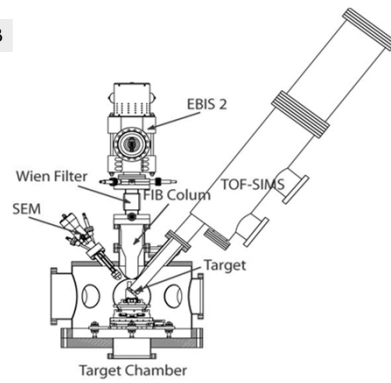
| Time of Flight<br>Secondary Ion Mass Spectroscopy   |
|---|
| <b>Anwendungen</b>  |
| Semiconductor industry  |
| Surface analysis  |
| "Soft matter" applications (bio materials, polymers, ... )  |
| Materials science   |
| Basic research  |
| Classical industry (glass, paper, metal, ceramics, ... )  |
| Analysis of contaminations, adhesion, friction, corrosion, diffusion, cell chemistry, bio compatibility |



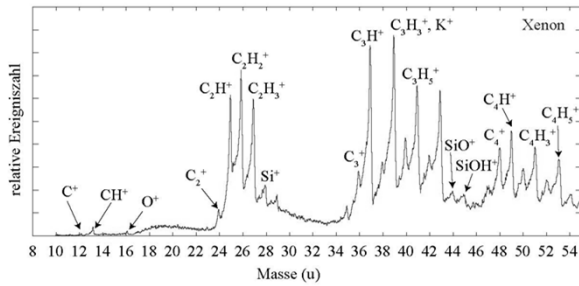
TOF-SIMS

Wien filter

FIB



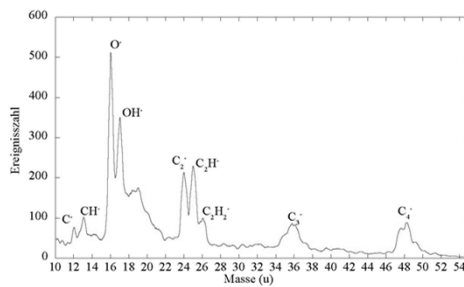
# Applications of HCI TOF-SIMS



Non-cleaned Si-surface

Excitation with xenon ions

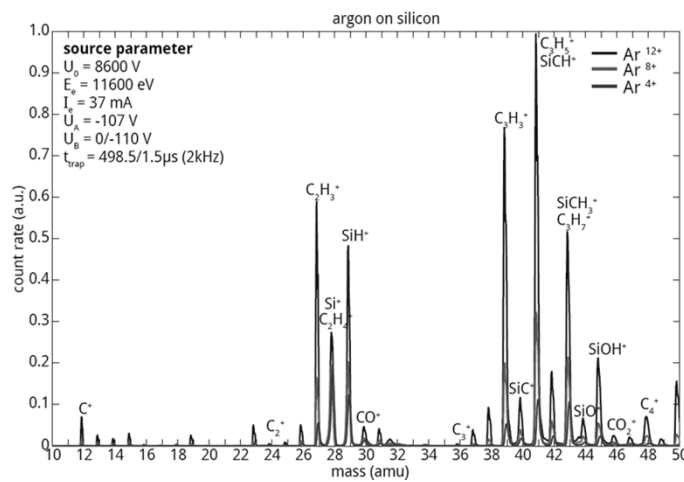
Positive ions



negative ions

11. Mai 2012

# Applications of HCI: TOF-SIMS

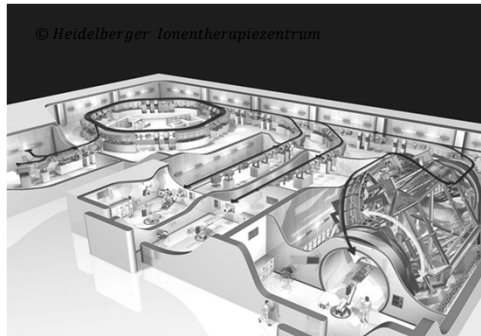


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11. Mai 2012

# Hadron Therapy



- **Cancer is the the second most common cause of death and about 33% of all inhabitants of the EU will confront some kind of cancer in their life**
- **About 45% of cancer patients can be treated, mainly by surgery and / or radiation therapy [S.Peggs, PAC07, June 25'07]**
- **Hadron therapy with protons and carbon ions is - taken its success rate - the second most successful technique in cancer treatment, outmatched only by surgery**
- **Until 2005 about 40.000 patients worldwide were treated by particle therapy at 22 PT centers (Europe, USA, Japan, China, South Africa). The number of treated patients is constantly increasing.**

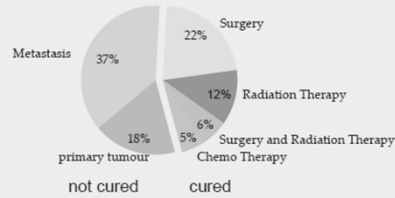
## Advantages of Therapy with Ion Beams



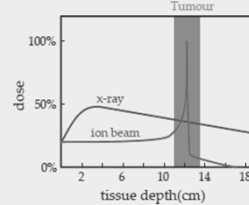
It is possible to focus carbon ions with great precision directly onto the tumor. Therefore, only the tumor is damaged irreversibly but the healthy tissue remains intact.

Another advantage is the high biological efficiency of carbon ions, causing more damage in the tumor cells than other kinds of irradiation.

### Cancer Therapy



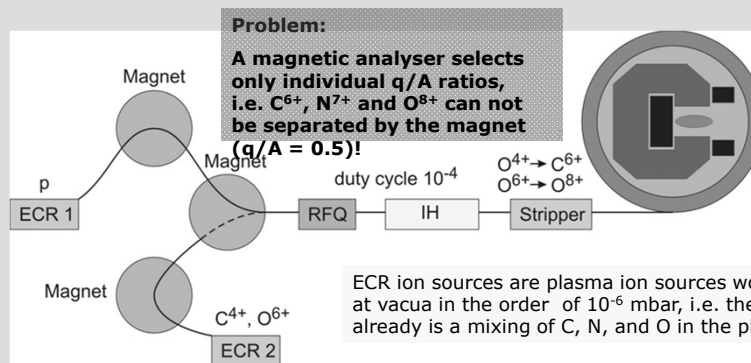
### Advantages of Ion Therapy



## Basic Structure of a Synchrotron-based Irradiation Facility



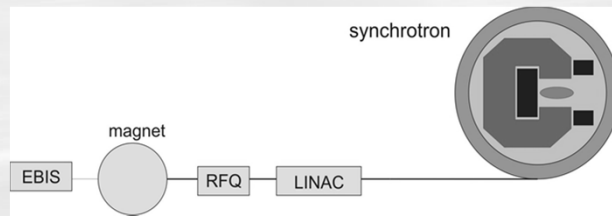
### Heidelberg Hadron Therapy Facility HIT:



R.Becker, ICIS-05 PA9/RSI MS # C05005

Seite 92

# Simplification of Therapy Facilities by using a New Kind of Ion Source



**Advantages:**

- only one ion source
- only one separation magnet
- shorter LINAC
- no stripper
- lower injection energy
- single-turn injection (at 4 MeV/u)
- smaller synchrotron magnets
- lower power consumption

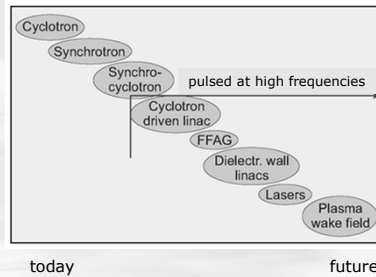


**the complexity of the irradiation facility decreases,**  
**the beam quality is improved,**  
**costs can be reduced**

# Particle therapy

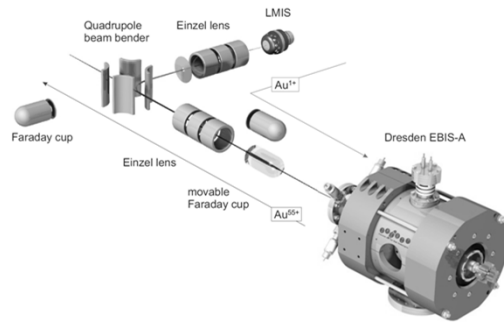


|  |   |
|--|---|
|  | <p><b>Cyclotrons</b></p> <ul style="list-style-type: none"> <li>• IBA (Belgium)</li> <li>• SIEMENS (Germany)</li> <li>• HITACHI (Japan)</li> <li>• MITSUBISHI (Japan) a.o.</li> </ul> |
|  | <p><b>Synchrotrons</b></p> <ul style="list-style-type: none"> <li>• SIEMENS (Germany)</li> <li>• HITACHI (Japan)</li> <li>• MITSUBISHI (Japan) u.a.</li> </ul>                        |
|  | <p><b>CYCLINACs</b></p> <ul style="list-style-type: none"> <li>• ADAM (Switzerland; CERN)</li> </ul>  |
|  | <p><b>DDA, DWA</b></p> <ul style="list-style-type: none"> <li>• SIEMENS (Germany)</li> <li>• some instituts (USA, Japan)</li> </ul>   |

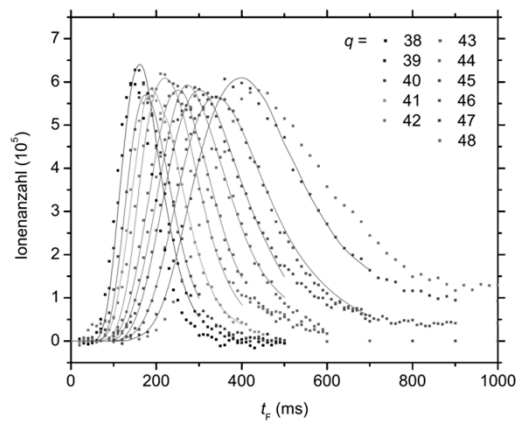


# Charge Breeding

# Charge Breeding



# Charge Breeding



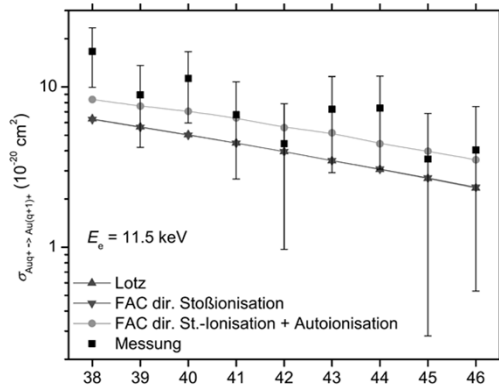
q/A analysis  
 → Evolution of the ion charge states Au<sup>38+</sup> to Au<sup>48+</sup>

Description:

$$dN_{q+}/dt = \lambda_{q-1} \cdot N_{q-1} - \lambda_q \cdot N_q + \lambda_{q+1} \cdot N_{q+1}$$



# Charge Breeding



Electron impact ionisation cross-sections for charge bred gold ions

# Thank you ... and thanks to the team!



Dr. G. Zschornack    R. Mertzig    U. Kentsch    E. Ritter



<http://www.tu-dresden.de>



Dr. V.P. Ovsyannikov    Dr. F. Grossmann    Dr. R. Heller    Dr. A. Thorn    M. Schmidt    M. Hartig



Dr. F. Ullmann    A. Schwan    J. König    M. Kreller



<http://www.dreebit.com>

Founding and cooperation

